

What nano-technology can do to create efficient and integrated components for THz heterodyne arrays

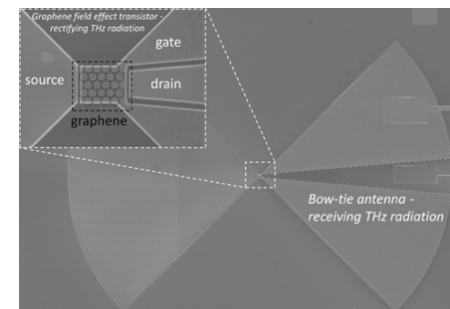
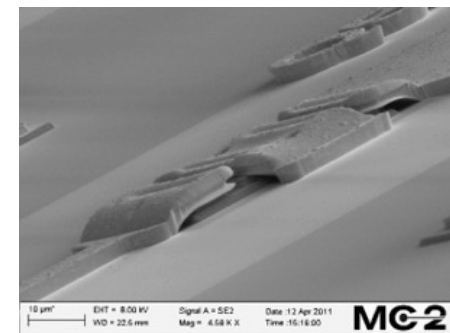
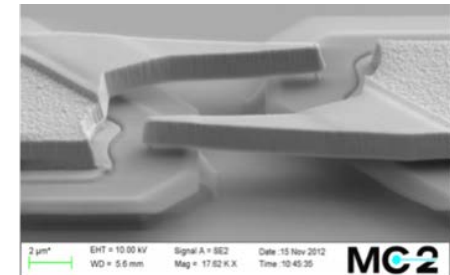
Jan Stake

THz heterodyne array workshop

Nunspeet, March 11, 2017

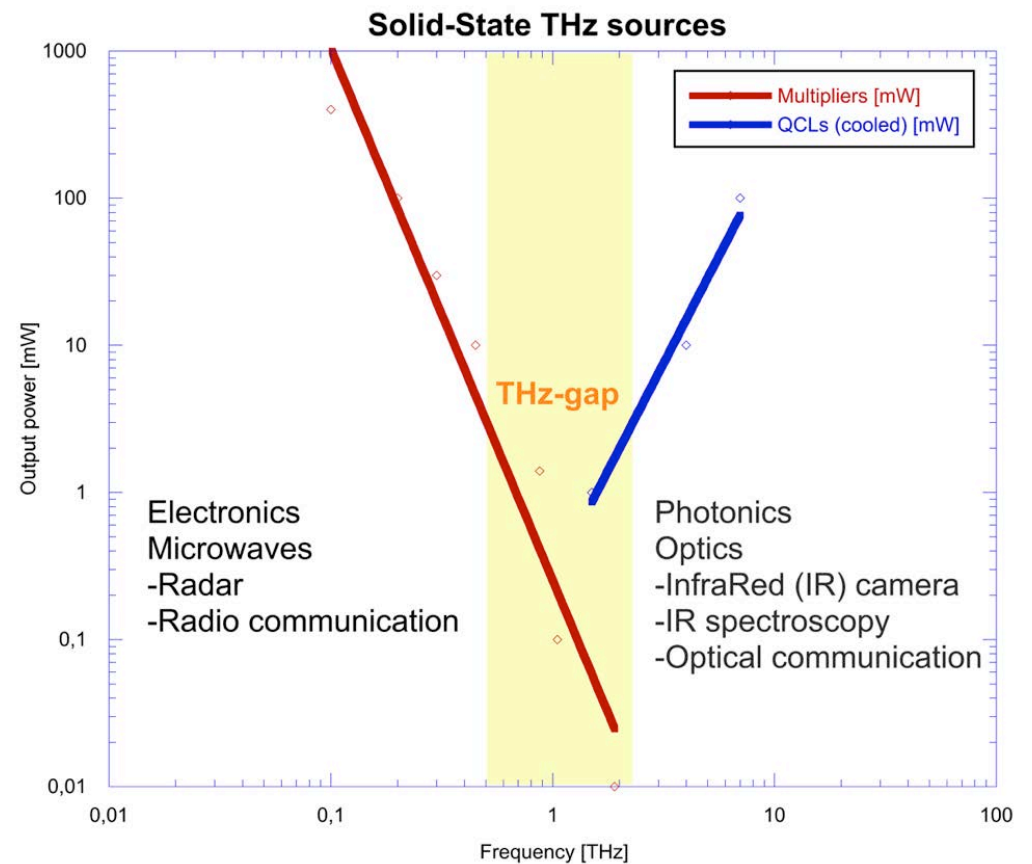
Outline

- ✧ **Background and motivation**
 - ✧ Challenges
- ✧ **Front-end electronics**
- ✧ **Frequency multipliers for LO signals**
 - ✧ HBV frequency multipliers
 - ✧ Single diode triplers and quintuplers
 - ✧ Grid multipliers
- ✧ **Heterogeneous integration for THz applications**
 - ✧ Heterogeneous integration
 - ✧ Integration approaches
 - ✧ Integrating THz electronics
- ✧ **Nano electronics**
 - ✧ Graphene

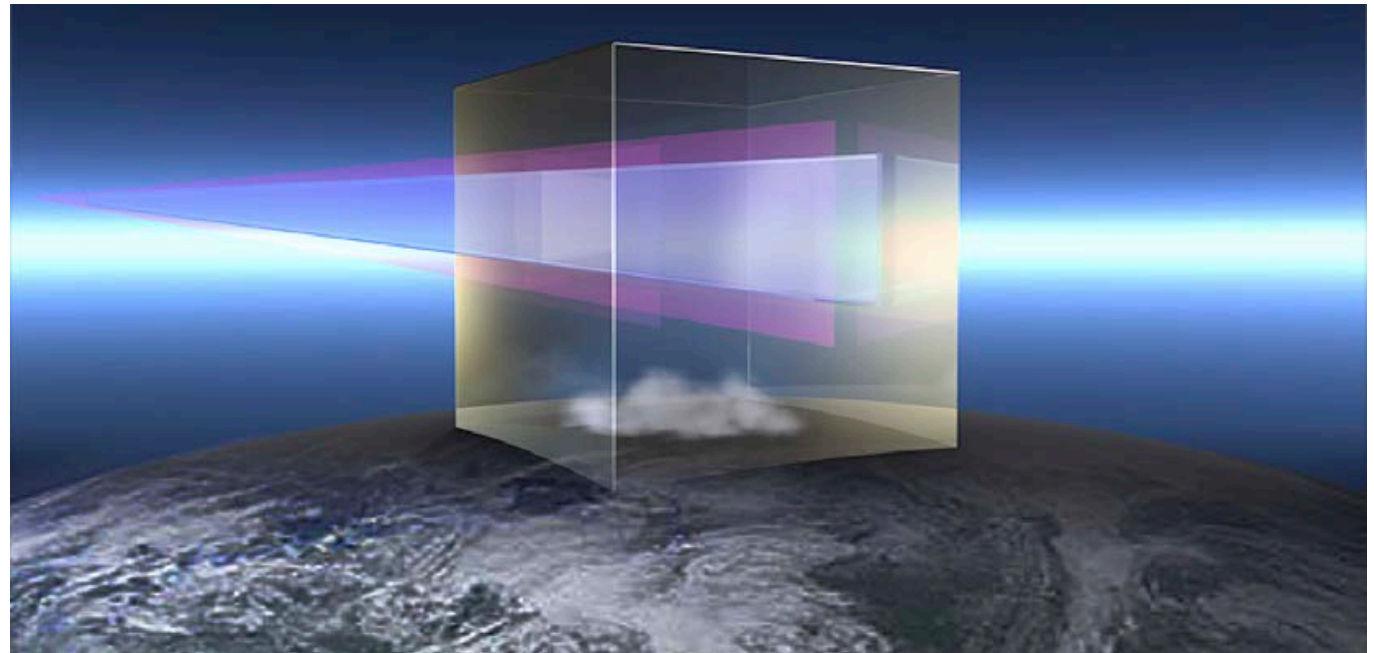


Research challenges

- ⚙ Multi-pixel and heterodyne arrays
- ⚙ Increase in output **power**
- ⚙ Reduce total power requirement with better **efficiency**
- ⚙ **Integration** and how to build complex circuitry



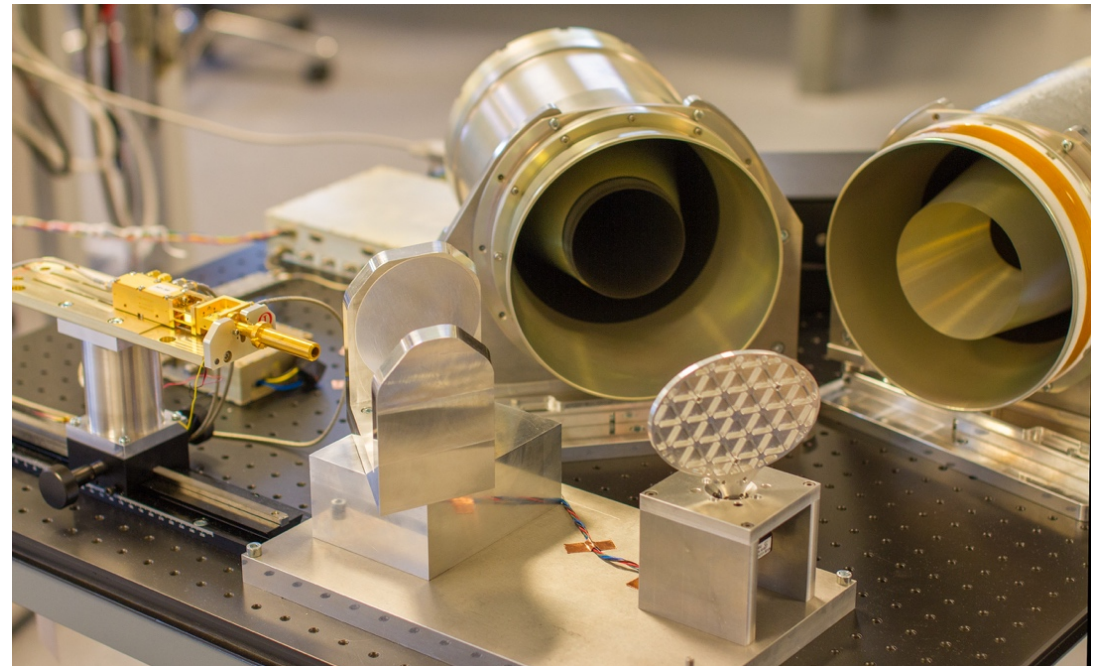
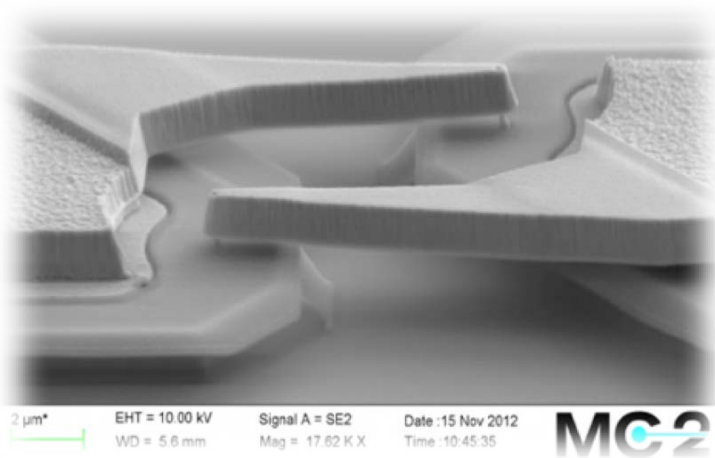
SteamR (Stratosphere Troposphere Exchange And Climate Monitor Radiometer)



Array of heterodyne Schottky diode receivers

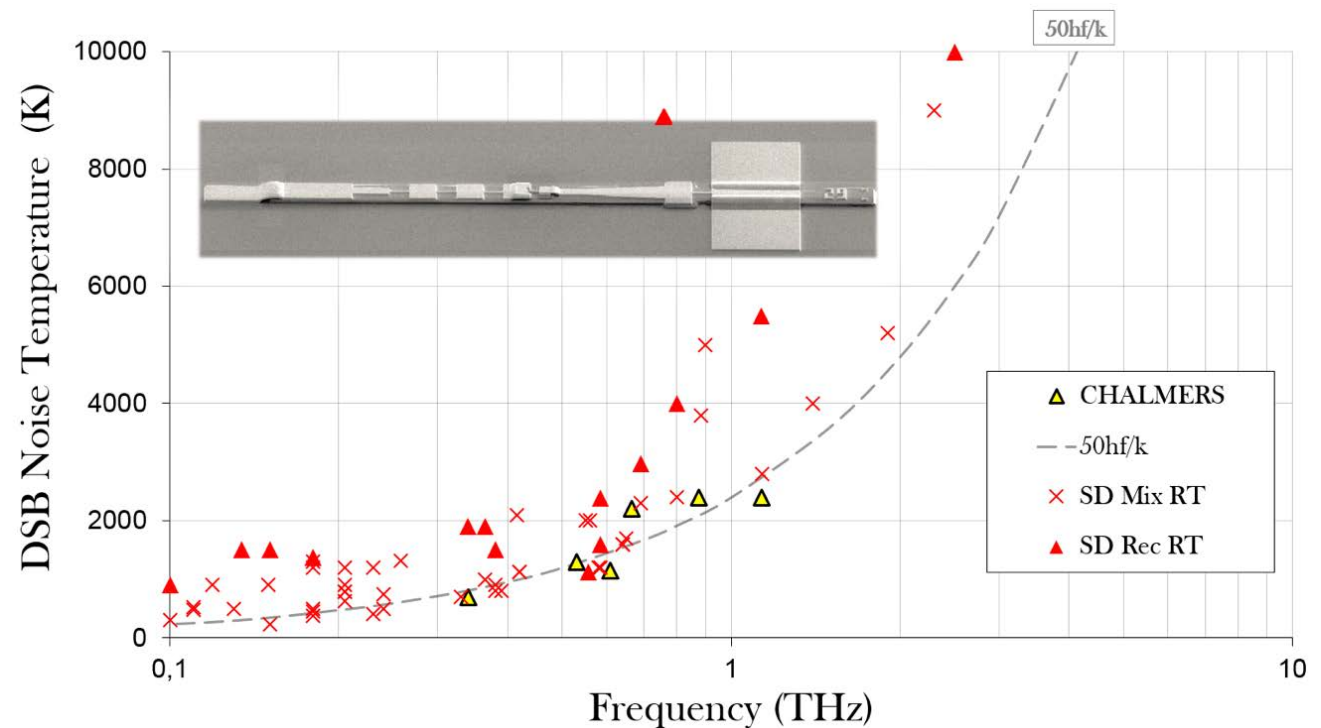
Front-end electronics

- High efficiency
- Integrate several functions

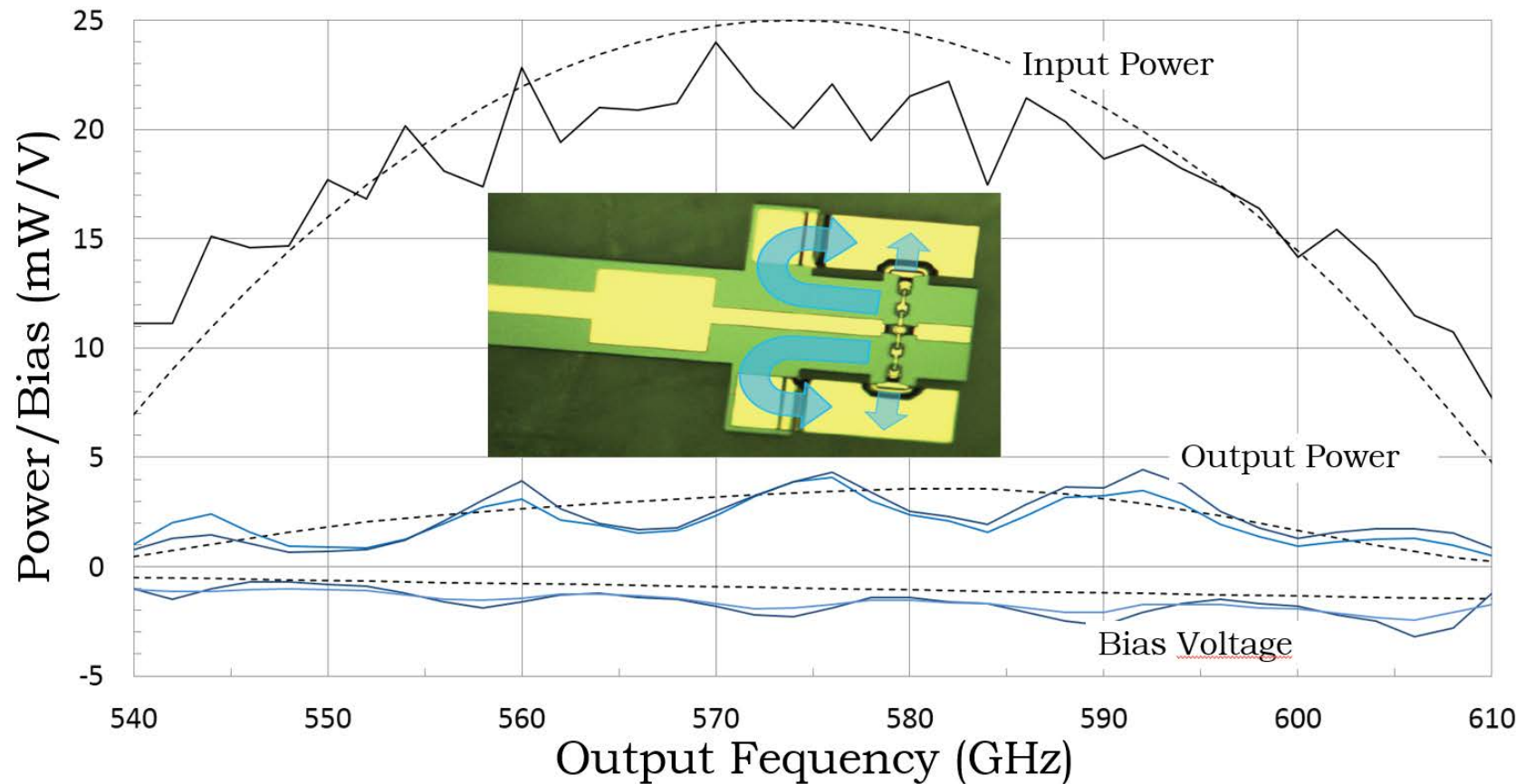


Schottky TMIC process / mixers

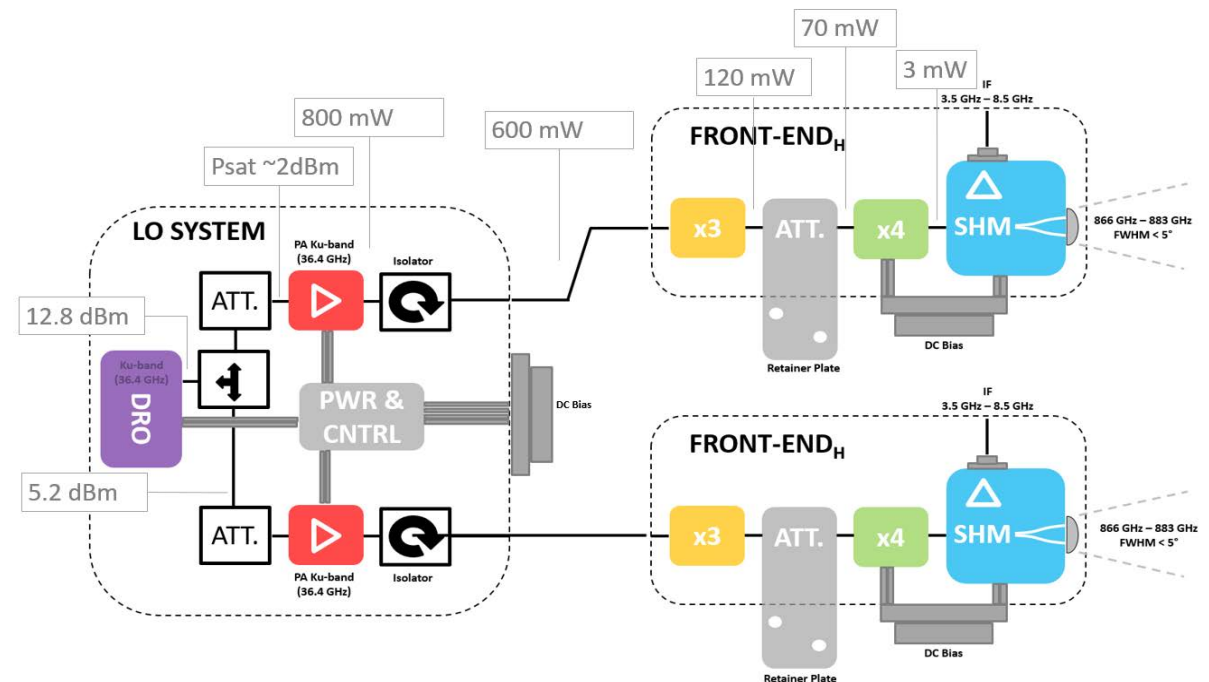
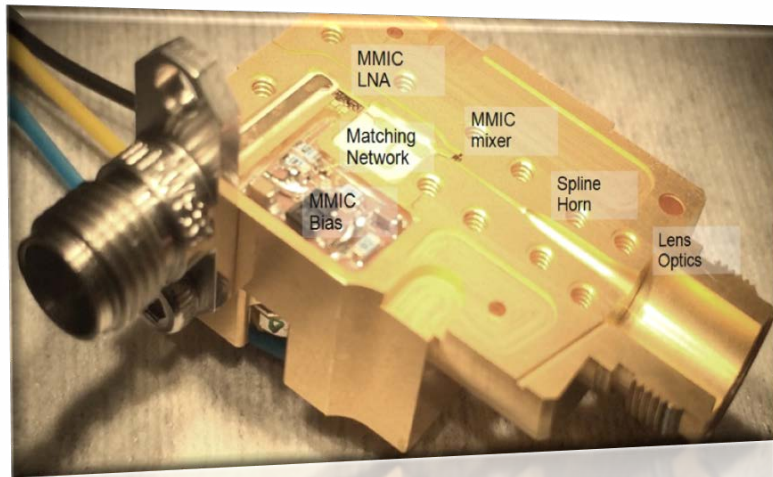
- ⚙ Integrated on thin GaAs membrane forming a suspended stripline technology
- ⚙ Devices as small as $0.1 \mu\text{m}^2$
- ⚙ Undergoing LAT for 2nd generation MetOp



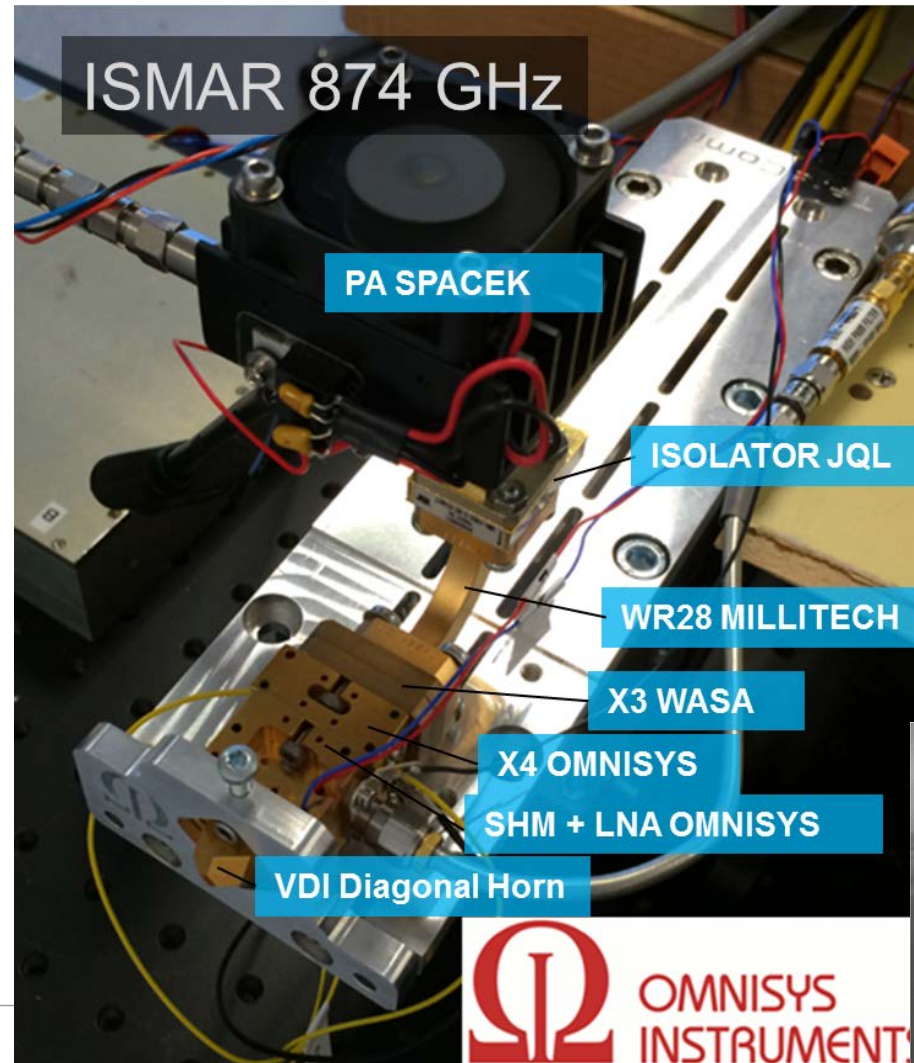
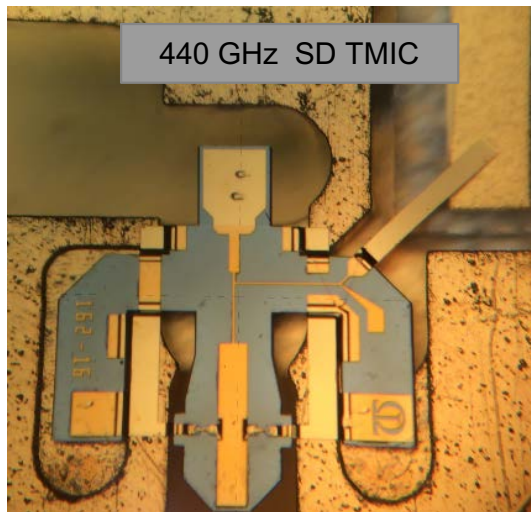
Schottky TMIC process / multipliers



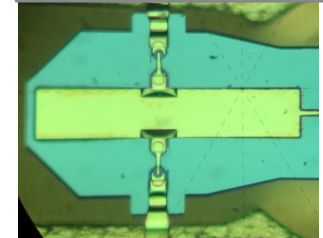
875 GHz Receiver Front-end for an Airborne Icecloud Imager Demonstrator



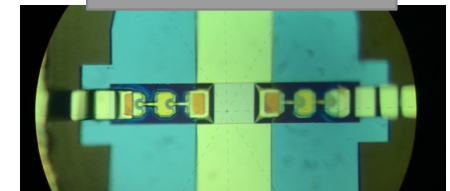
200 mW @ 110 GHz ($\eta \sim 20\%$)
25 mW @ 220 GHz ($\eta \sim 30\%$)
5 mW @ 440 GHz ($\eta \sim 20\%$)
 $T_{r,min} \sim 2500$ K



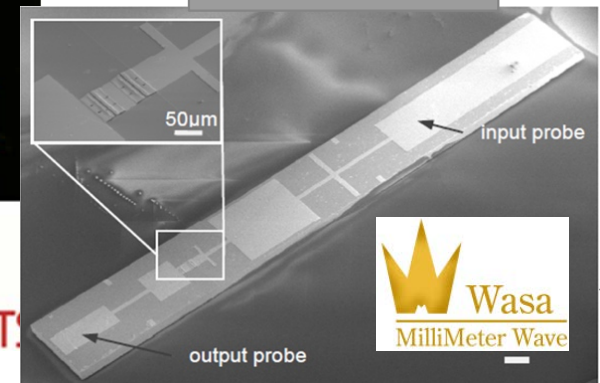
440 GHz SD TMIC



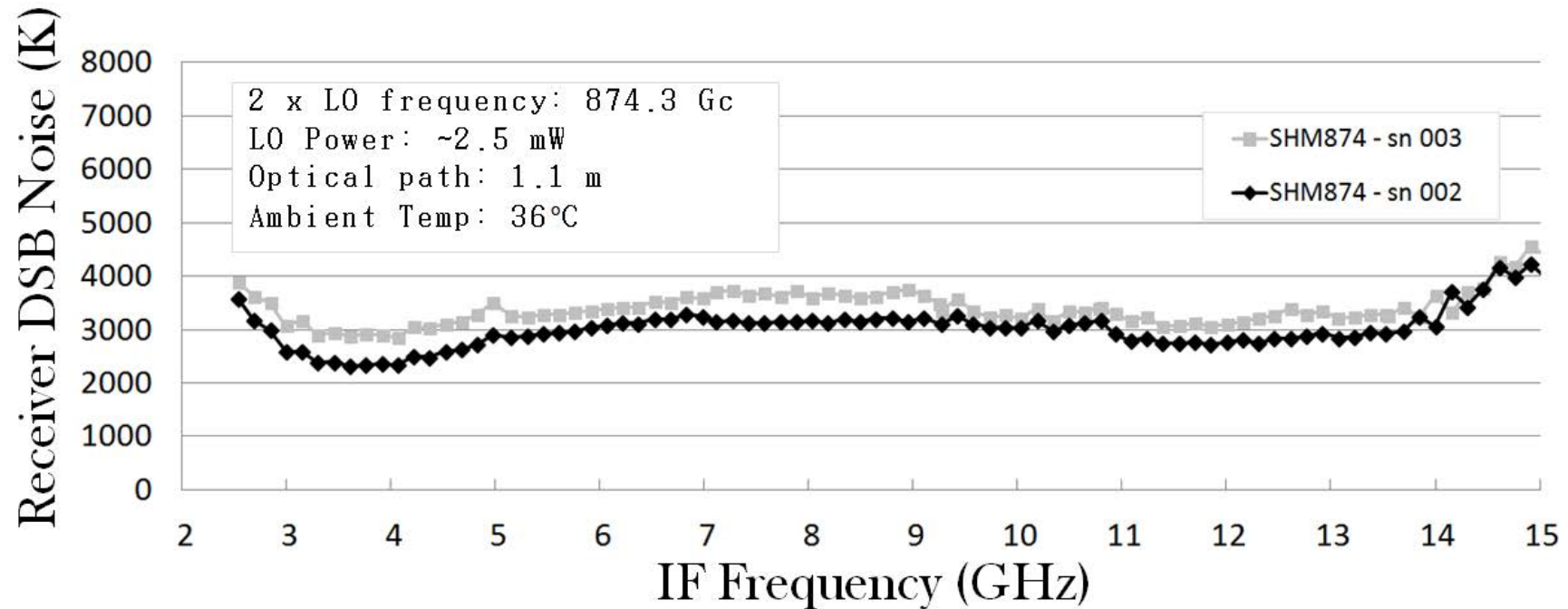
220 GHz SD TMIC

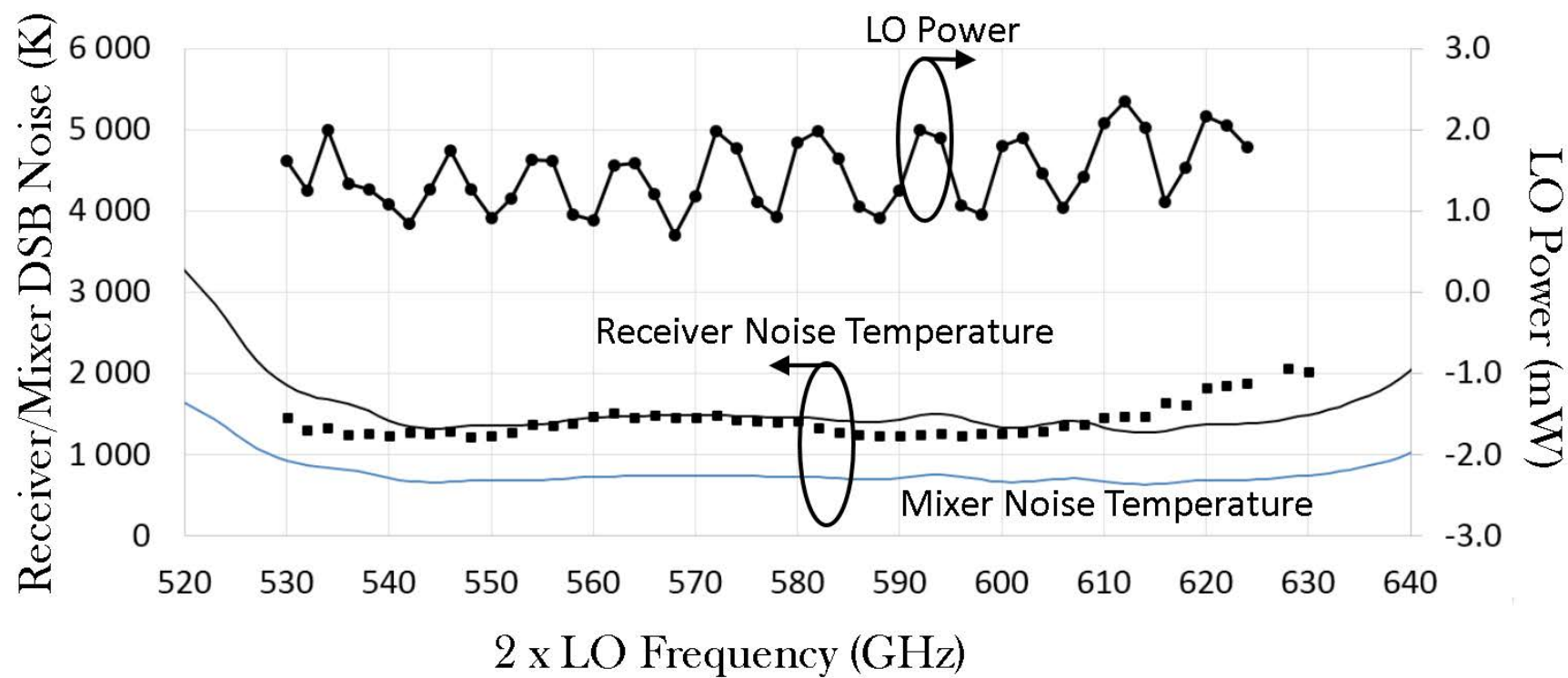


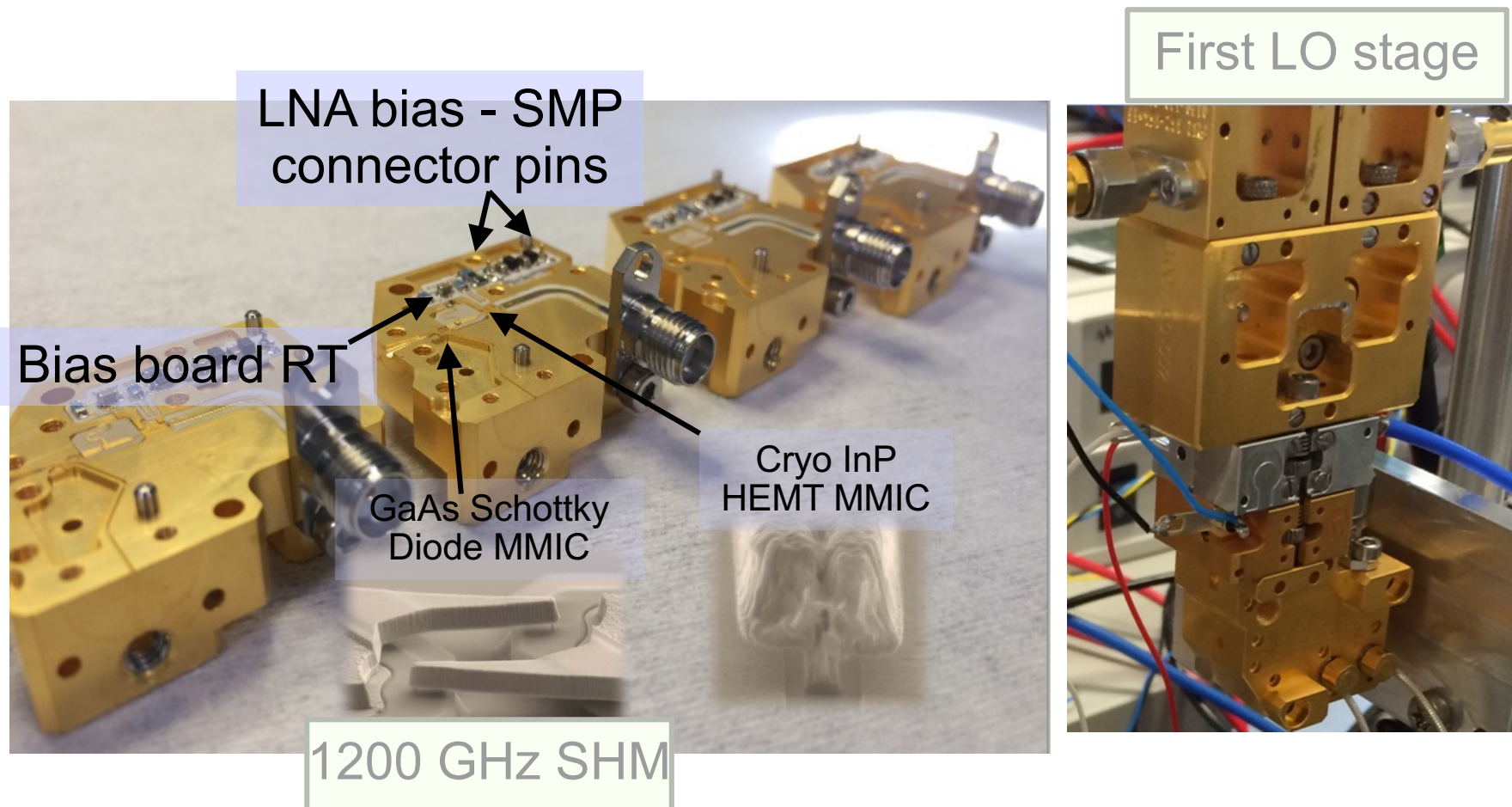
110 GHz X3 MMIC

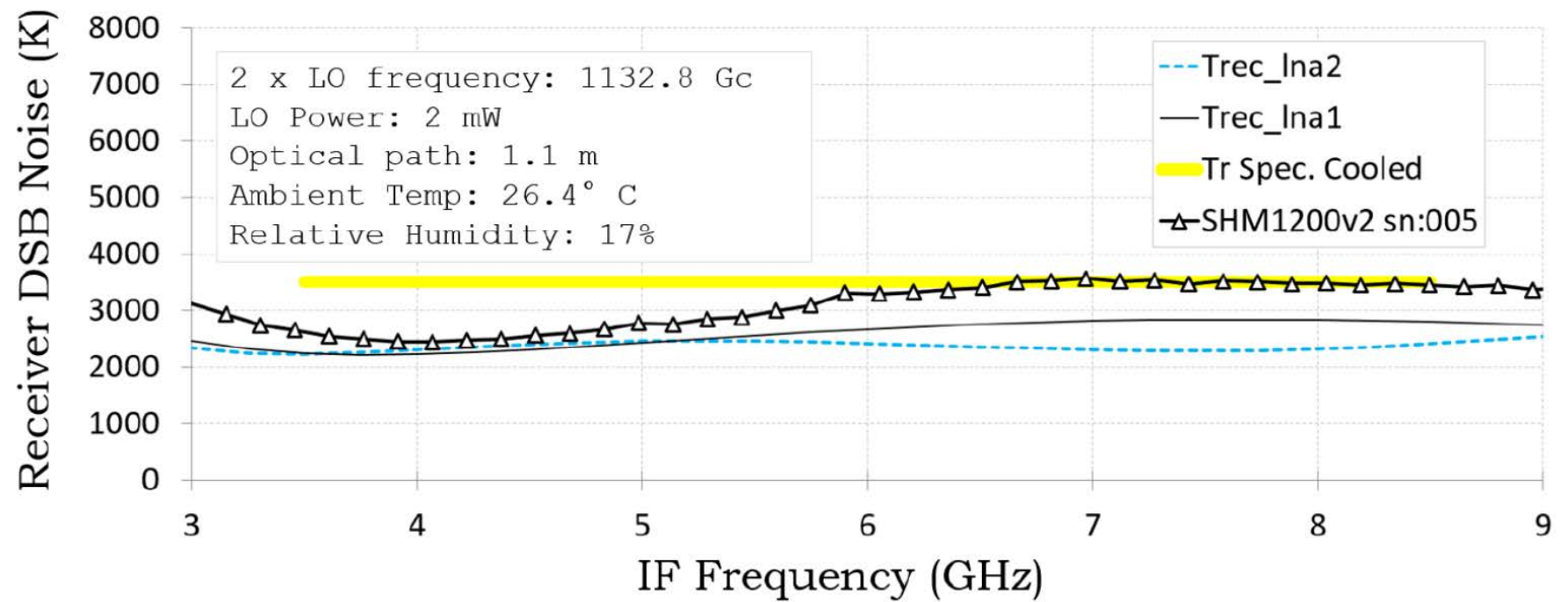


ISMAR receiver performance

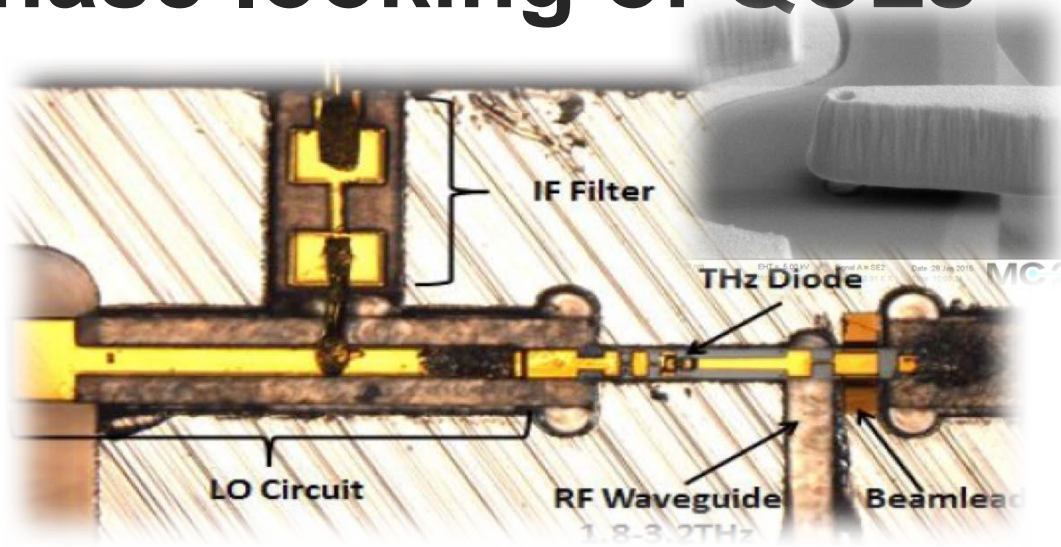








1.8-3.2 THz harmonic mixers phase looking of QCLs



Courtesy of Virginia Diodes, Inc.

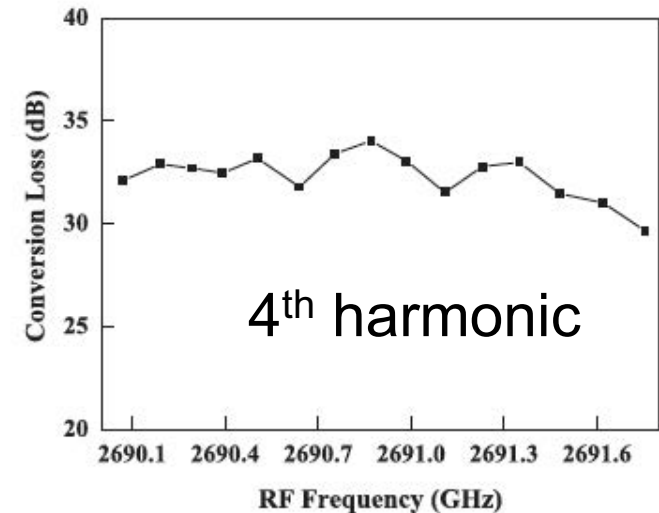
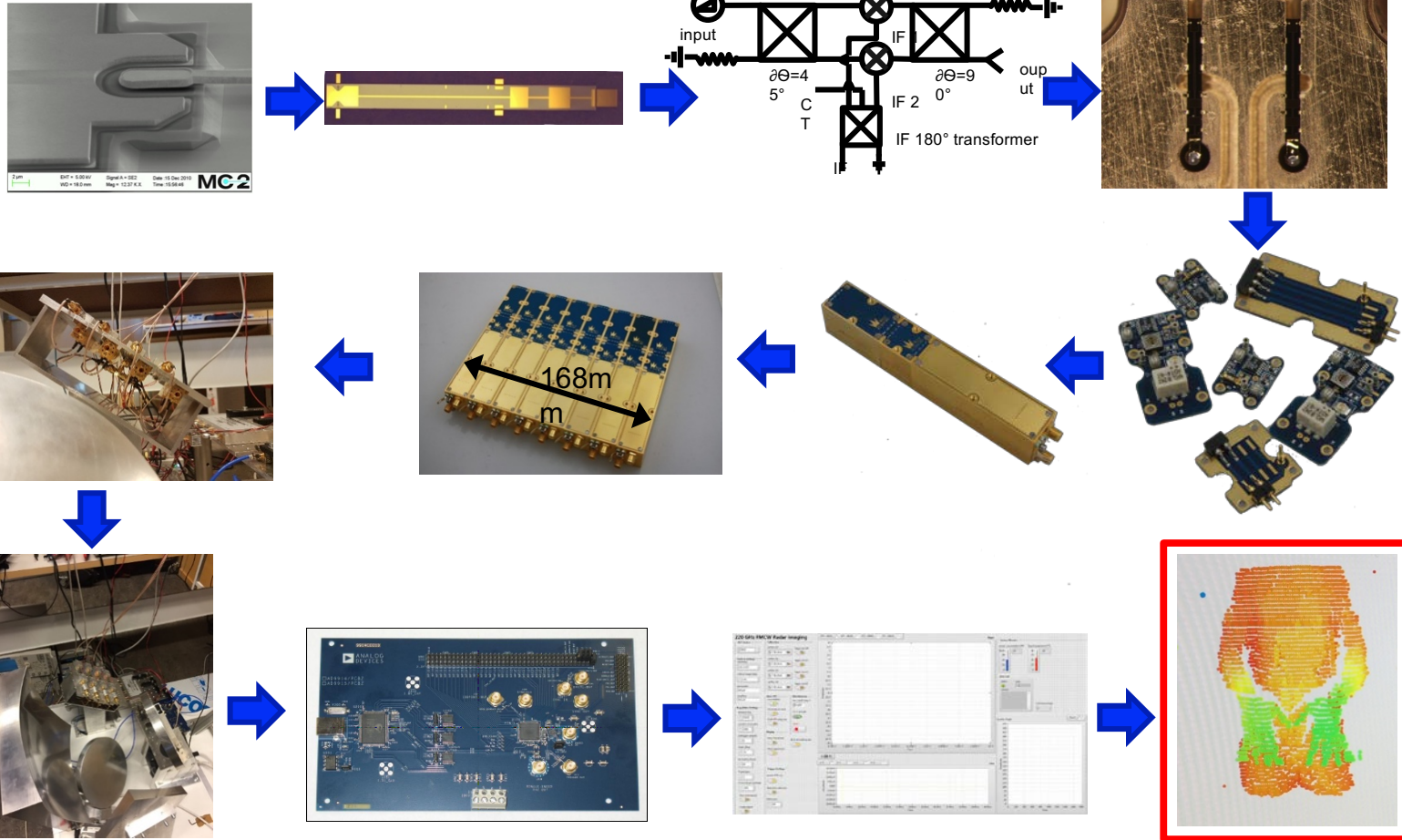


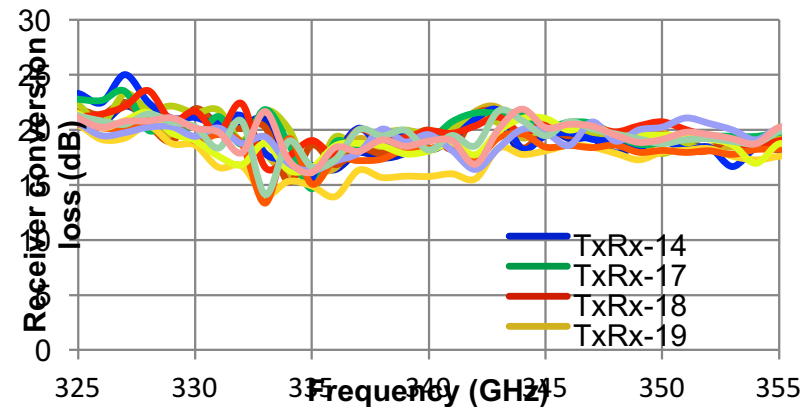
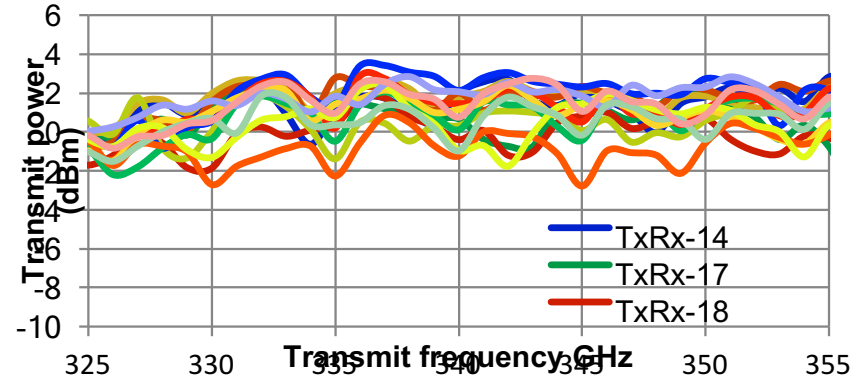
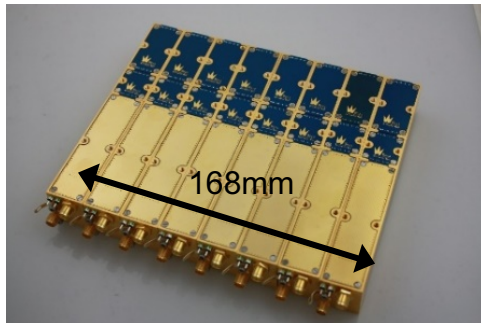
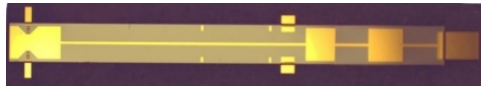
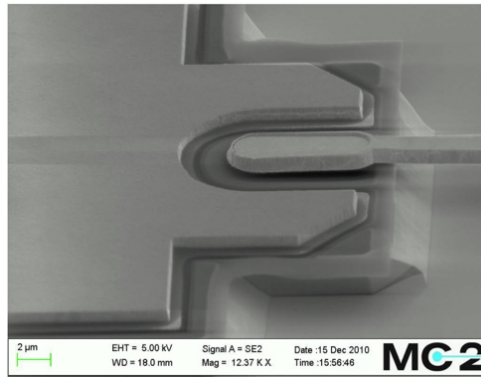
Fig. 20. Conversion loss of the harmonic mixer tested using 2690–2691.8 GHz QCL.

B. T. Bulcha, J. L. Hesler, V. Drakinskiy, J. Stake, A. Valavanis, P. Dean, L. H. Li, and N. S. Barker, "Design and characterization of 1.8–3.2 THz Schottky-based harmonic mixers," *IEEE Trans. Terahertz Sci. Technol.*, vol. 6, no. 5, pp. 737–746, Aug. 2016.

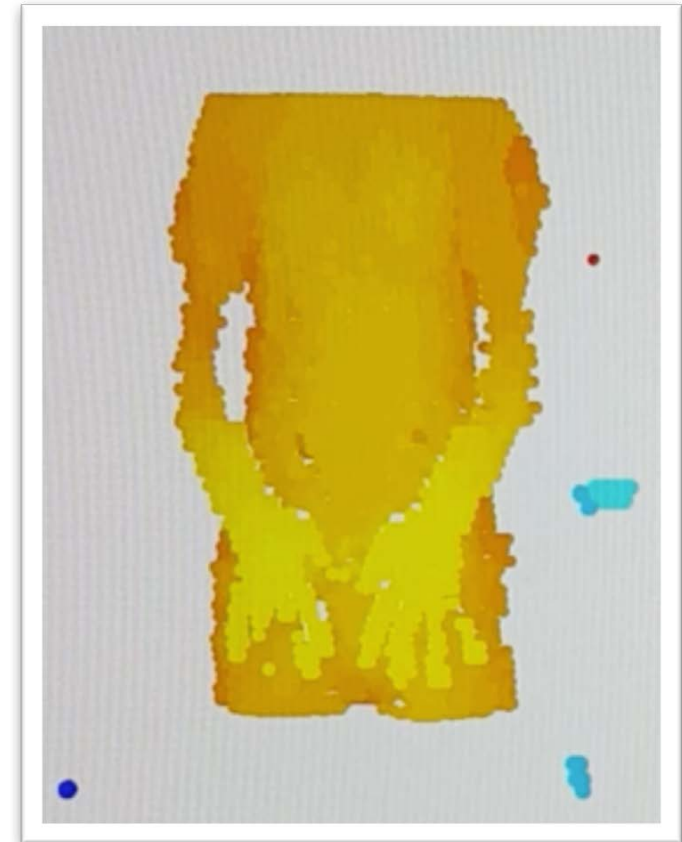
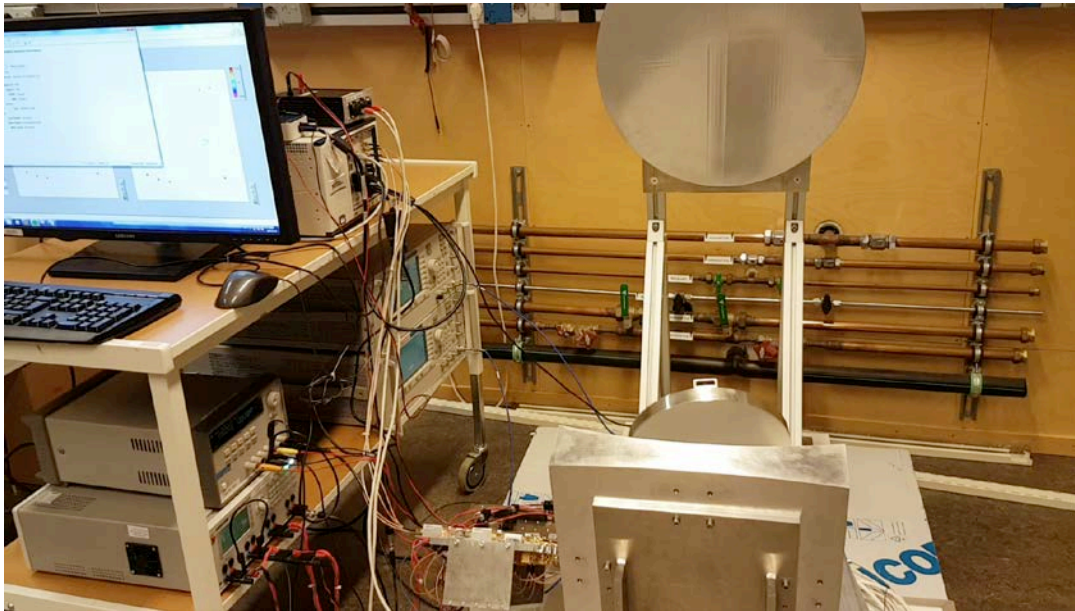
3D radar: from device to system



15 TxRx modules at 340 GHz

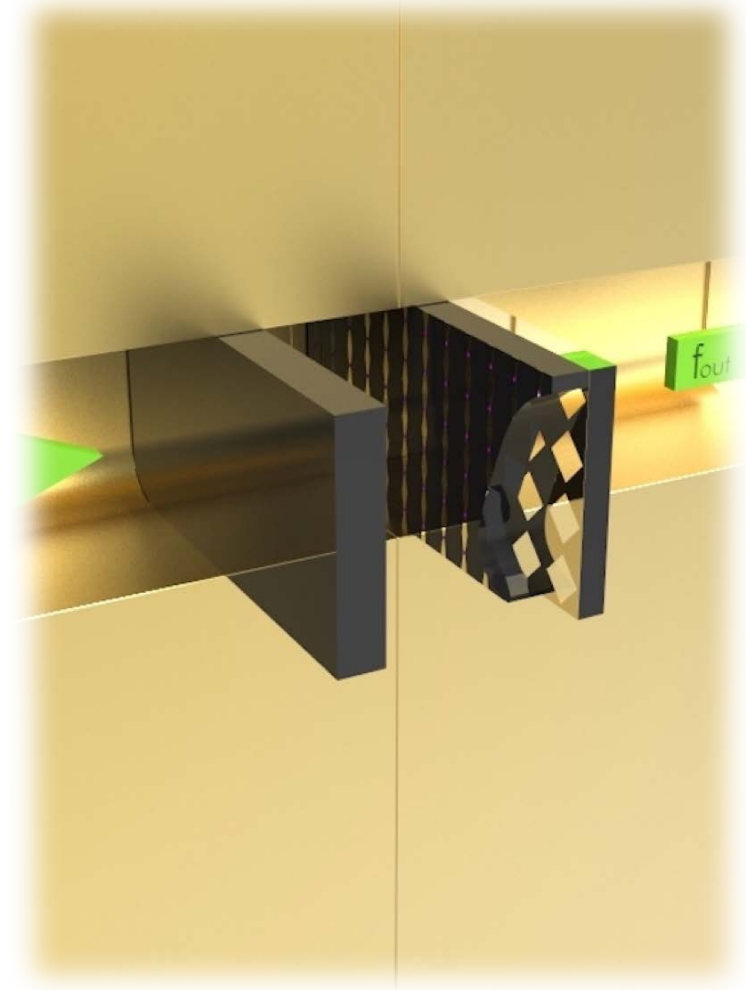
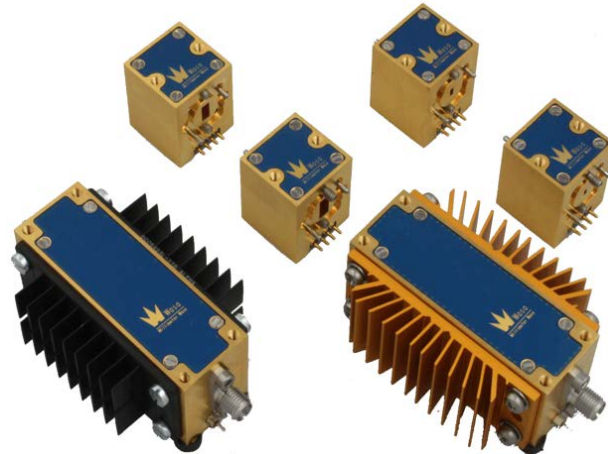


220GHz 3D FMCW THz radar



Solid-state sources

- High efficiency
- Medium power
- Power scaling



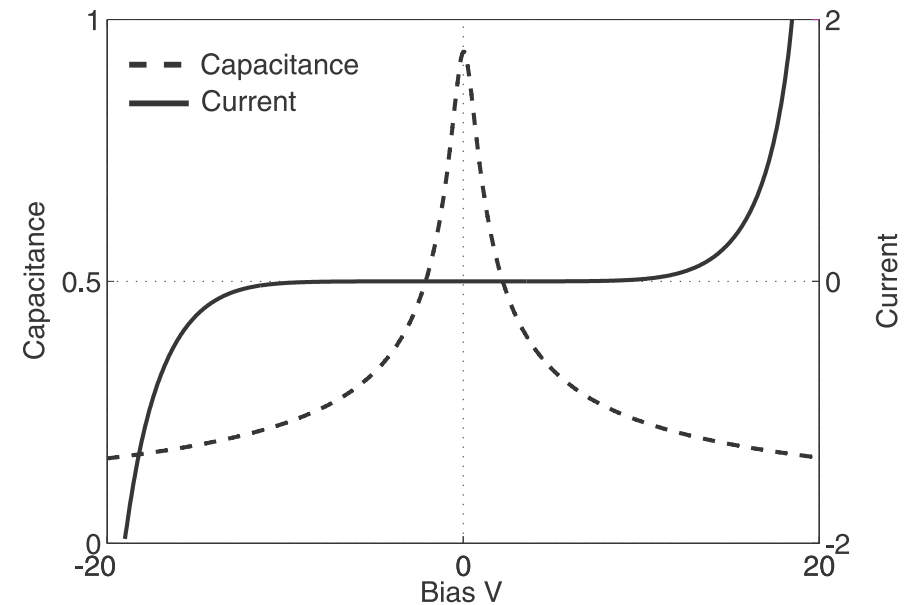
High power amplifiers

- ⚙ High power GaN technology
- ⚙ W-band amplifiers



Heterostructure Barrier Varactor (HBVs) frequency multipliers

- ⚙ High output power
- ⚙ Ultra compact
- ⚙ No bias circuitry
- ⚙ High multiplication x3, x5, x7
- ⚙ Chalmers invention

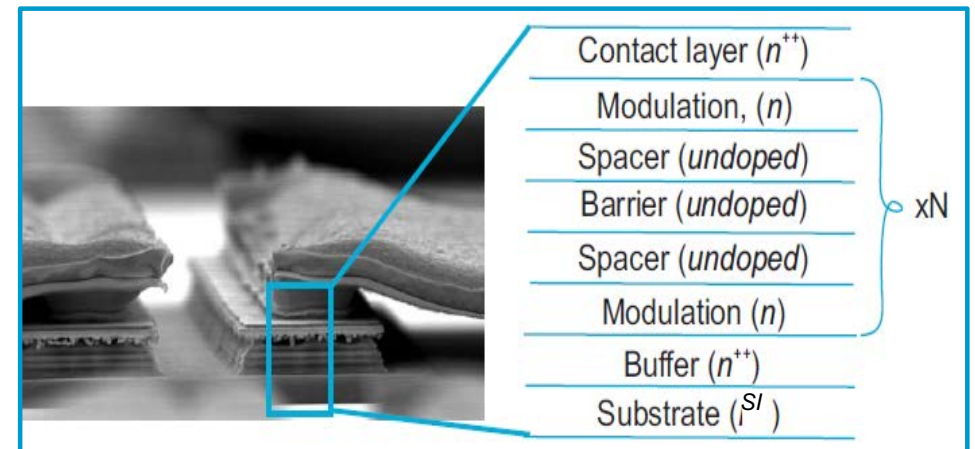
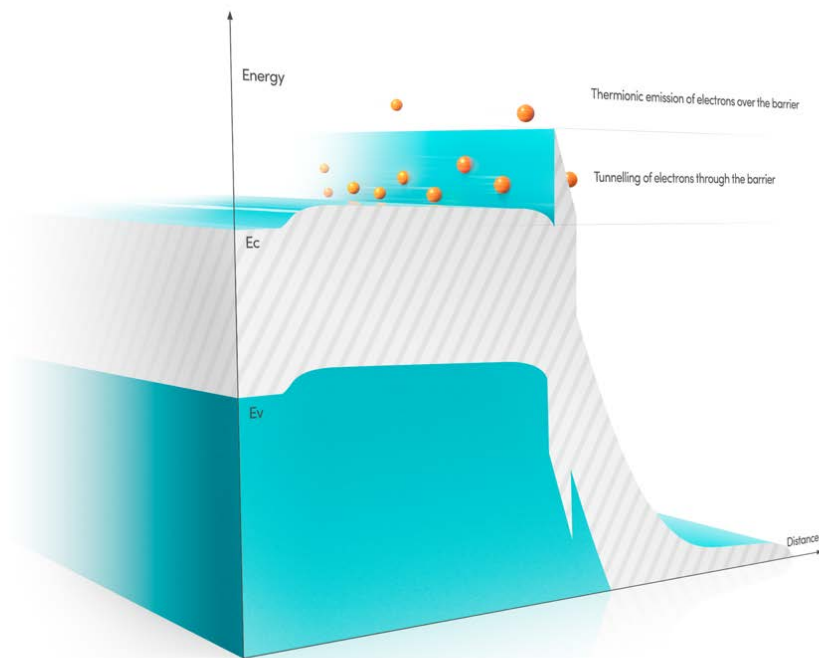


Courtesy of



Providing more power and reducing system complexity

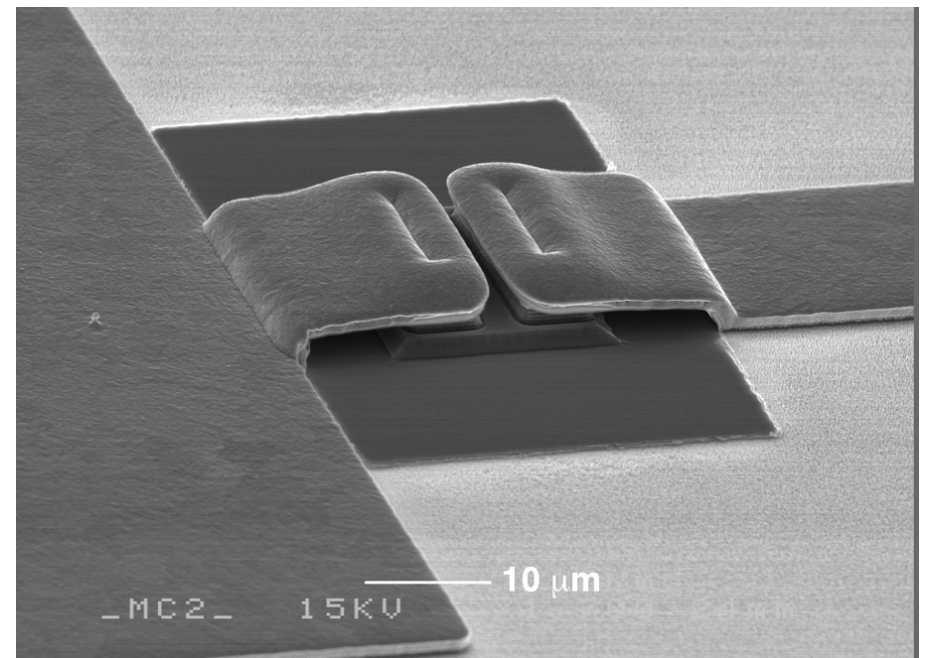
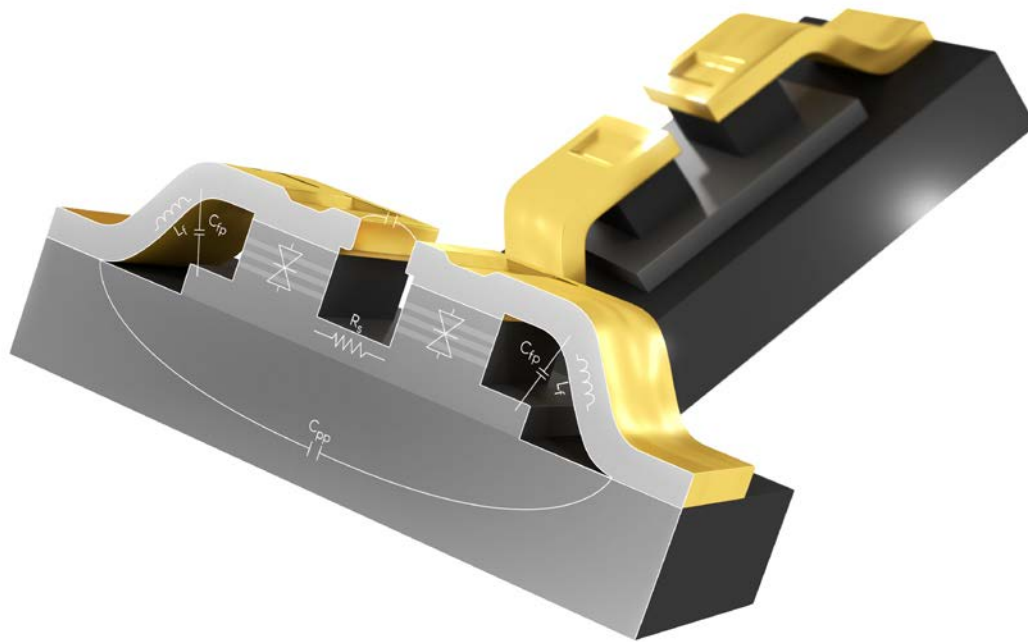
HBV diodes



- Epitaxial growth
- $\text{In}_{0.53}\text{Ga}_{0.47}\text{As}/\text{In}_{0.52}\text{Al}_{0.48}\text{As}$ on InP
or GaAs/AlGaAs on GaAs
- Low – high – low bandgap material
- Symmetric capacitance modulation

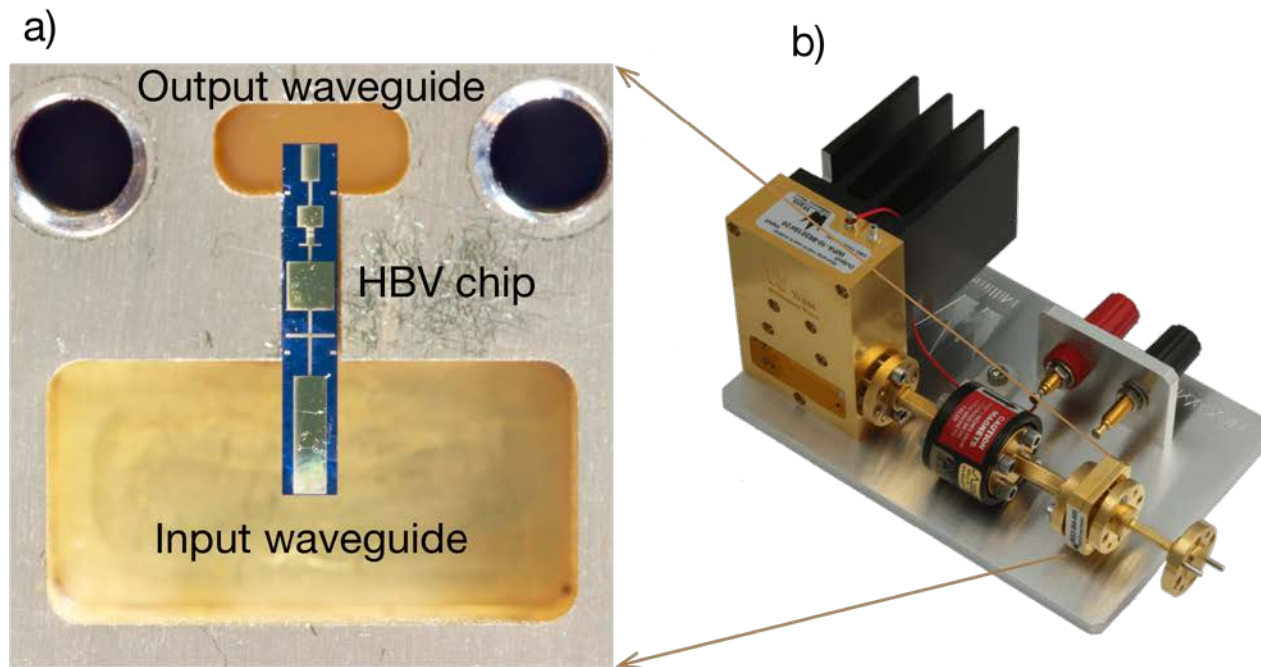
J. Stake, A. Aleksandra, T. Bryllert, and J. Vukusic, "Status and Prospects of High-Power Heterostructure Barrier Varactor Frequency Multipliers," *Proc. IEEE*, 2017.

HBV diodes



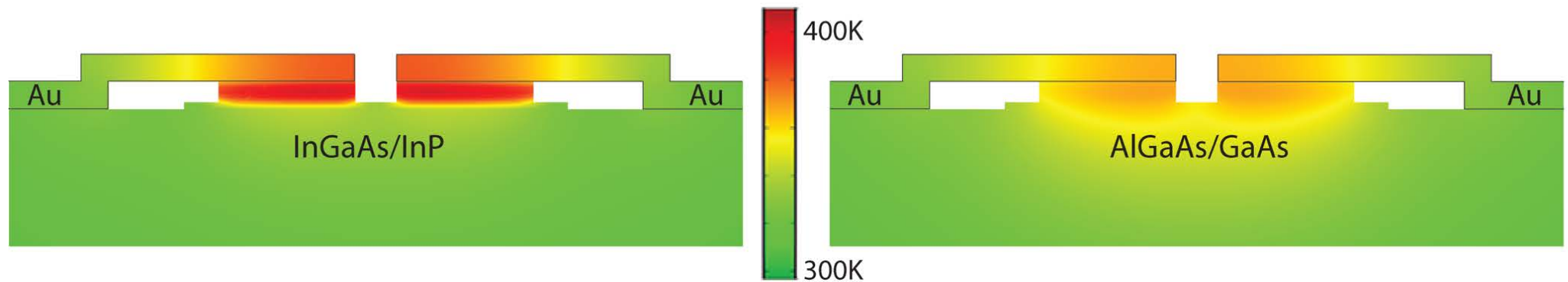
J. Stake, A. Aleksandra, T. Bryllert, and J. Vukusic, "Status and Prospects of High-Power Heterostructure Barrier Varactor Frequency Multipliers," *Proc. IEEE*, 2017.

HBV multipliers



J. Stake, A. Aleksandra, T. Bryllert, and J. Vukusic, "Status and Prospects of High-Power Heterostructure Barrier Varactor Frequency Multipliers," *Proc. IEEE*, 2017.

Electrothermal optimisation

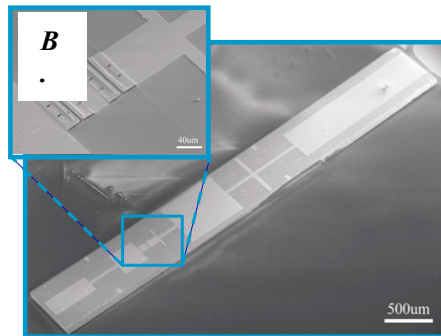


Best material for THz applications?

Diode – Circuit Integration Methods

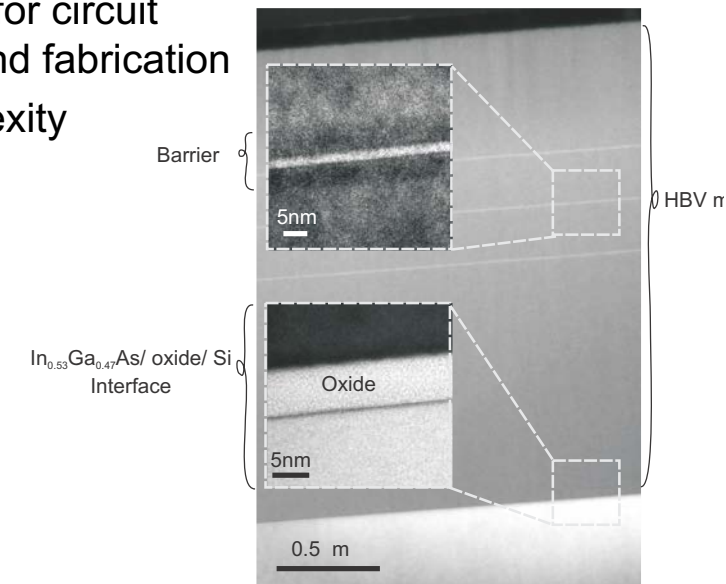
Monolithic

- + Passive and active components processed on the same substrate
- + Repeatability and reproducibility
- Limited choice of substrates



Heterogeneous

- + Materials with dissimilar physical properties
- + Increased performance and functionality
- + Additional degree of freedom for circuit design and fabrication
- Complexity



Heterogeneous Integration

Combining optimum active material with optimum substrate
- “no single technology will do it all”



Substrate material

- + Low RF losses
- + Mechanically robust/machinable
- + Thermal conductivity
- + High/low relative permittivity
- + Compatible with low freq/digital electronics CMOS compatibility
- + Material cost/ availability

Si, Diamond....



Active/device material

- + High mobility
- + Versatile bandgap engineering
- + Ohmic contact formation
- + Thermal conductivity

III-Vs, Graphene?

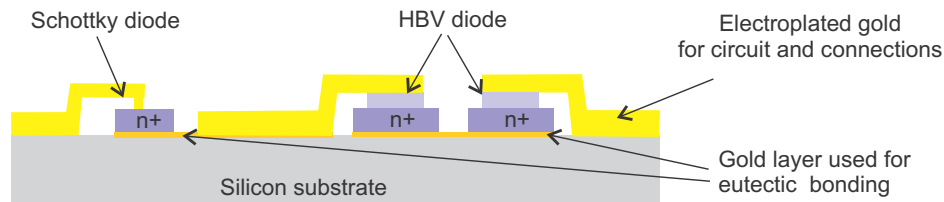
Heterogeneous Integration

Heterogeneous integration

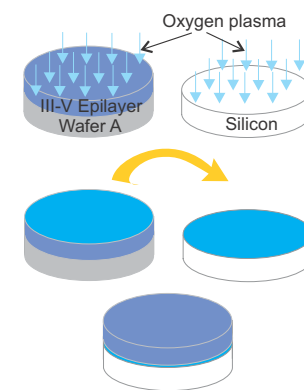
Lattice mismatched materials

- **Epitaxial growth**
 - Intermediate buffer layer
- **Epitaxial transfer**
 - Indirect: adhesive, eutectic
 - Direct: anodic, fusion, *plasma activated*

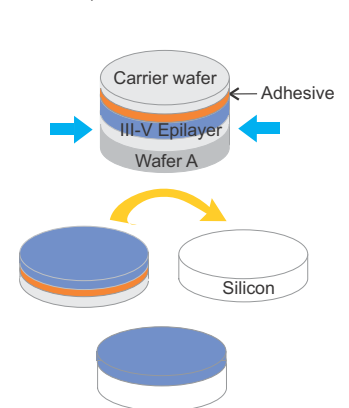
- **Multi-technology integration**



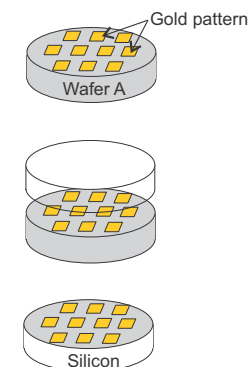
A) LOW-TEMPERATURE PLASMA-ASSISTED
WAFER BONDING



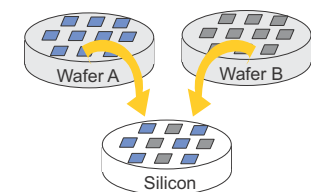
B) EPITAXIAL LIFT-OFF



C) EUTECTIC BONDING



D) PICK-AND-PLACE



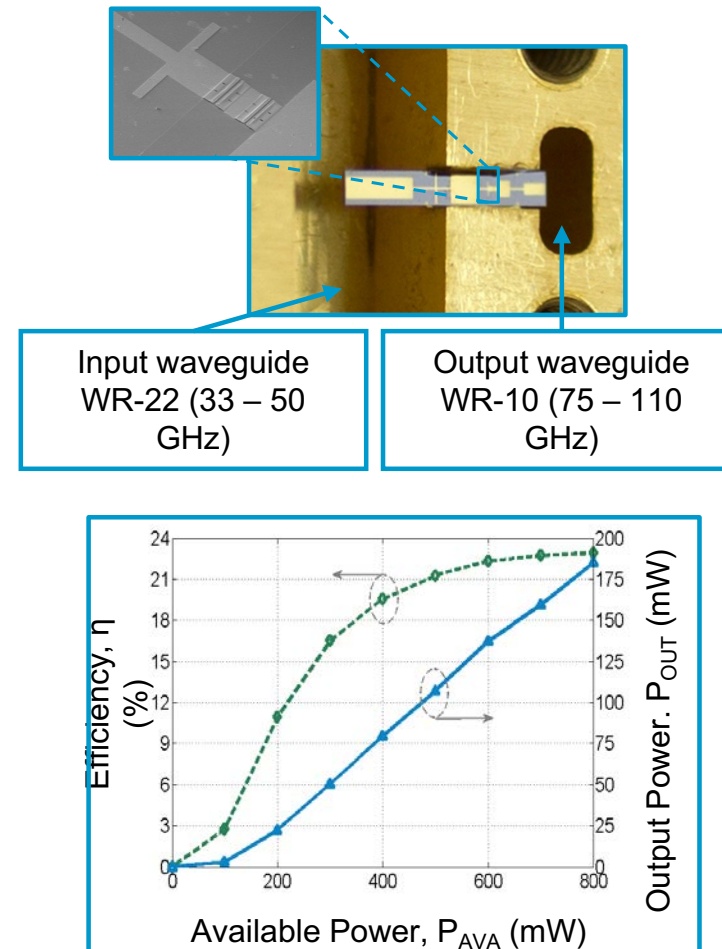
HBV multipliers: III-V on Silicon

	Si	InGaAs	InP as substrate
Mobility [cm^2/Vs]	500	12 000	5000
Thermal conductivity [$\text{Wm}^{-1}\text{K}^{-1}$]	150	≈ 4	68
Mechanical rigidity	Rigid/bendable when thin	brittle	brittle
Maturity	MEMS/CMOS		
Bandgap engineering		InGaAs/InAlAs/InP	InGaAs/InAlAs/InP
ϵ_r	≈ 12	≈ 12	≈ 12

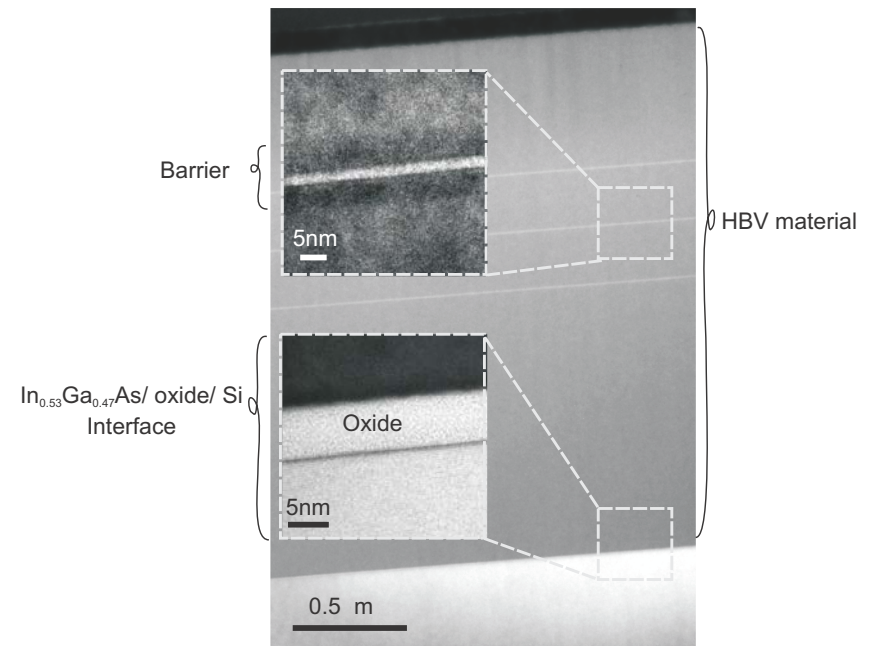
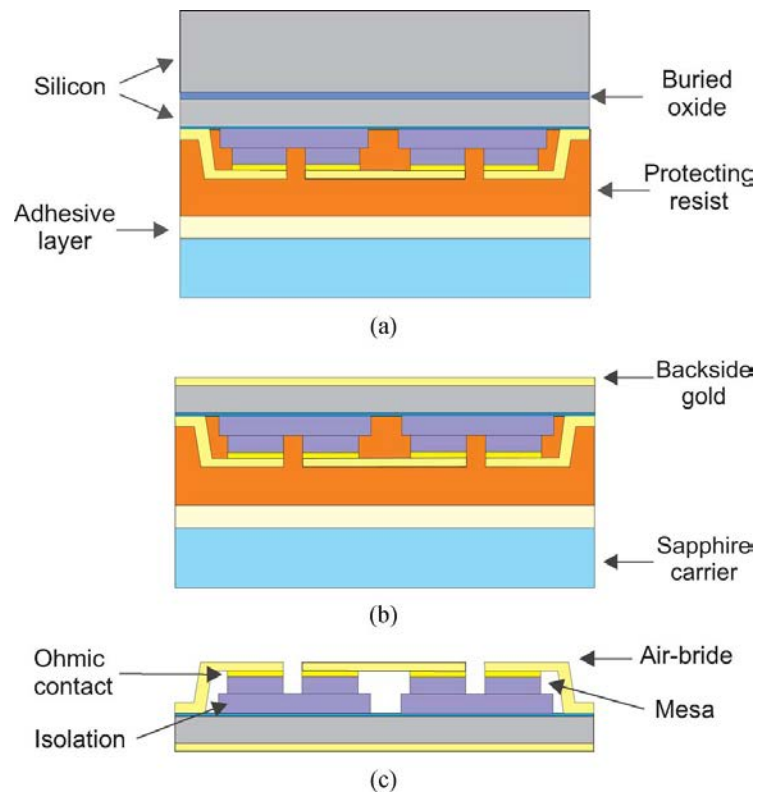
Reference: 100 GHz multiplier (MMIC) Monolithically integrated multiplier

Frequency tripler (×3)

- $\text{In}_{0.53}\text{Ga}_{0.47}\text{As} / \text{In}_{0.52}\text{Al}_{0.48}\text{As}$
- InP substrate
- Input Q-band (33 – 50 GHz)
- Output W-band (70 – 110 GHz)
- $f_{\text{CENTRE}} = 107 \text{ GHz}$
- < 0.2 W output power



Heterogeneously integrated multiplier

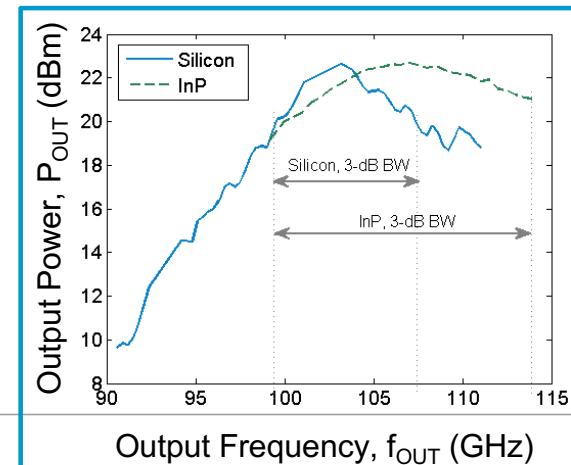
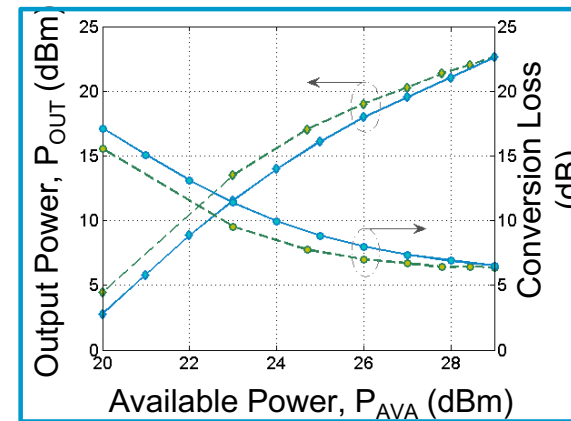


100 GHz multiplier

Heterogeneously integrated multiplier

Frequency tripler ($\times 3$)

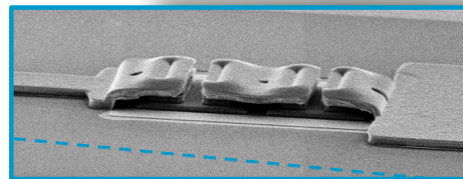
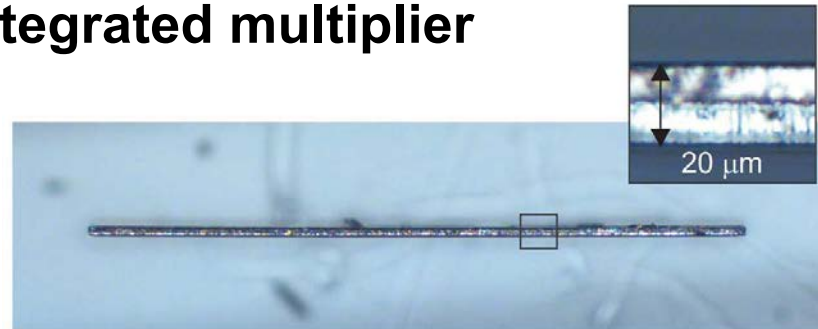
- Silicon substrate
 - Original design on InP
 - First demonstration
 - Robust circuits
-
- Similar RF performance
 - $f_{CENTRE, Si} = 103$ GHz
 - $f_{CENTRE, InP} = 107$ GHz
 - < 0.2 W output power (input power limited)



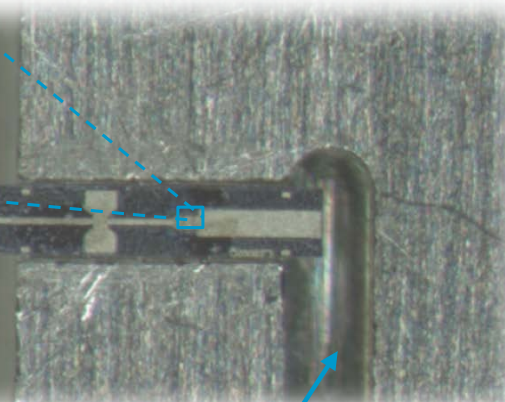
480 GHz quintupler / SOI technology

Heterogeneously integrated multiplier

SOI process / 20 μ m
thick Si-substrate



Input waveguide
WR-10 (70 – 110 GHz)



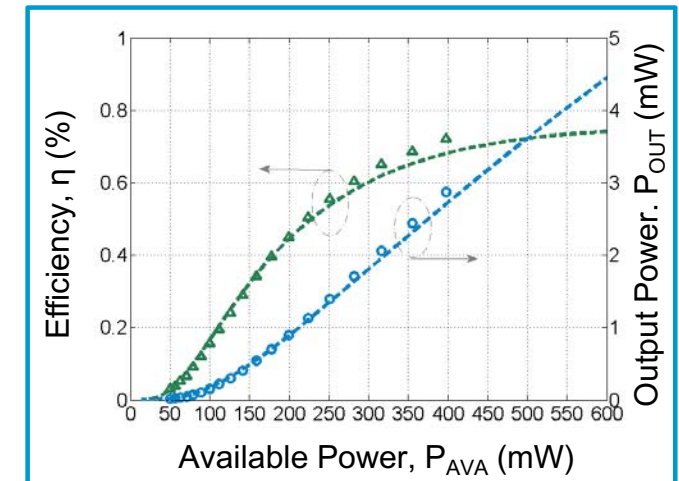
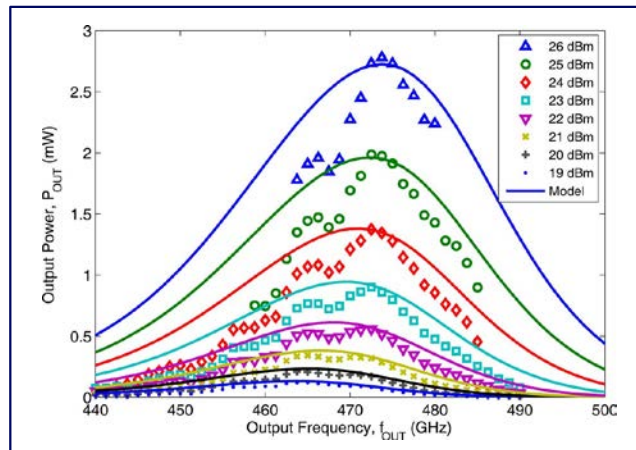
Output waveguide
WR-2.2 (400 – 500 GHz)

480 GHz quintupler / SOI technology

Heterogeneously integrated multiplier

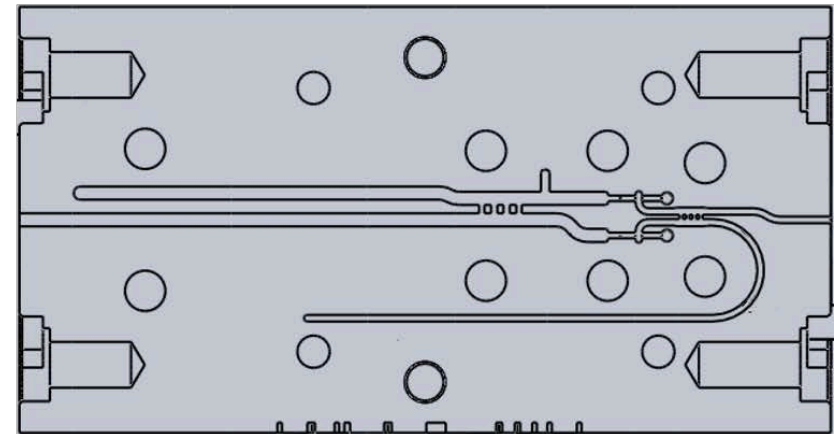
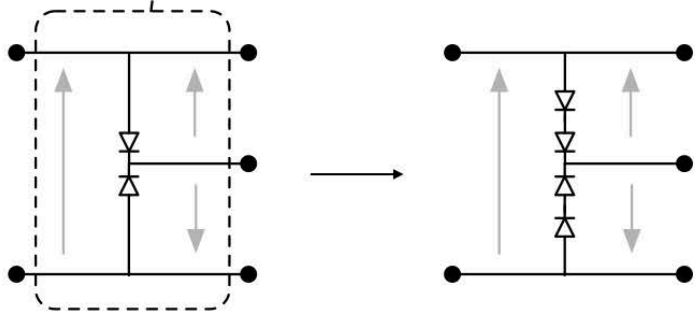
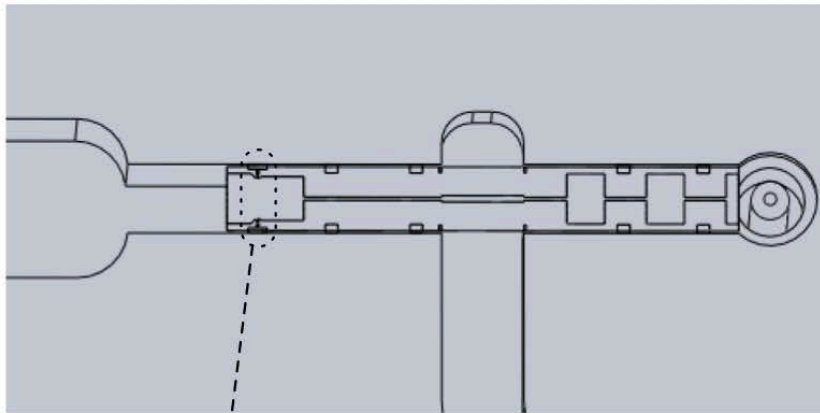
Frequency quintupler ($\times 5$)

- Silicon-on-insulator (SOI)
- Predefined thickness 20 μm
- Input W-band (75 – 110 GHz)
- Output WR – 2.2 (400 – 500 GHz)
- Highest frequency of operation
- < 3 mW output
- Limited by available input power ($> 5\text{ mW}$) measured



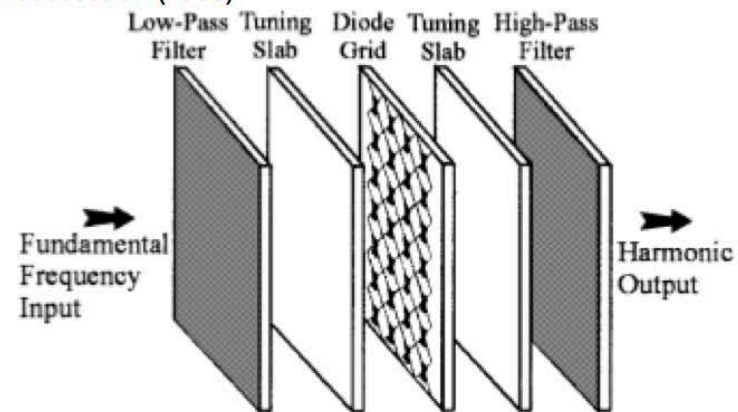
A. Malko, T. Bryllert, J. Vukusic, and J. Stake, "A 474 GHz HBV Frequency Quintupler Integrated on a 20 μm Thick Silicon Substrate," *IEEE Trans. Terahertz Sci. Technol.*, vol. 5, no. 1, pp. 85–91, 2015.

Classical power combining



Concept of grid power combining

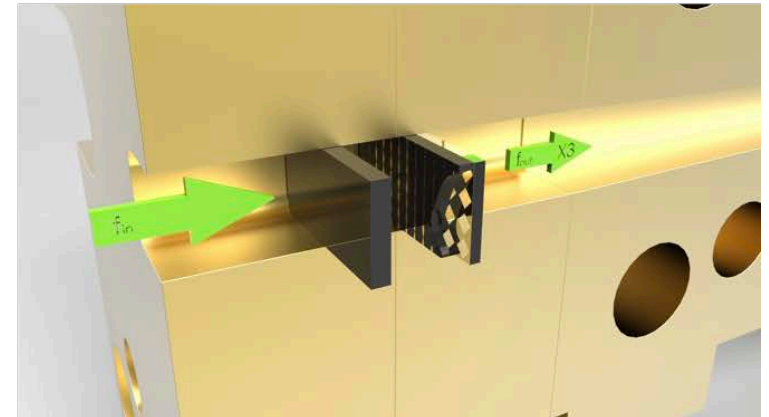
A. Moussessian (1998)



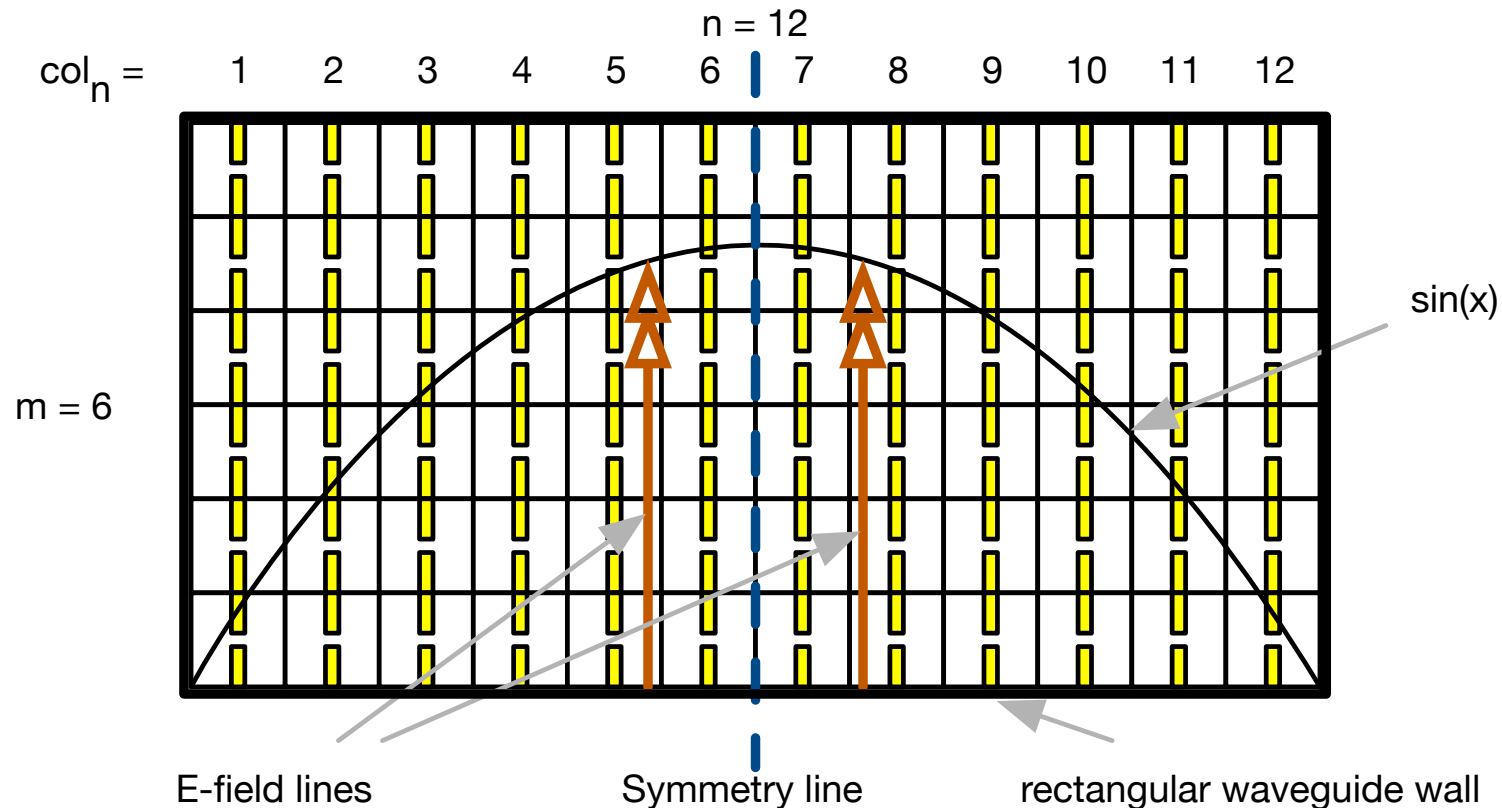
Free space

$P \sim m \times n$ devices

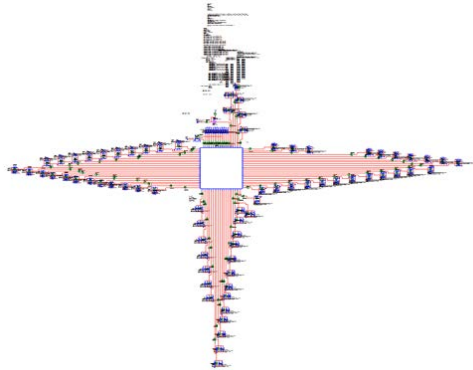
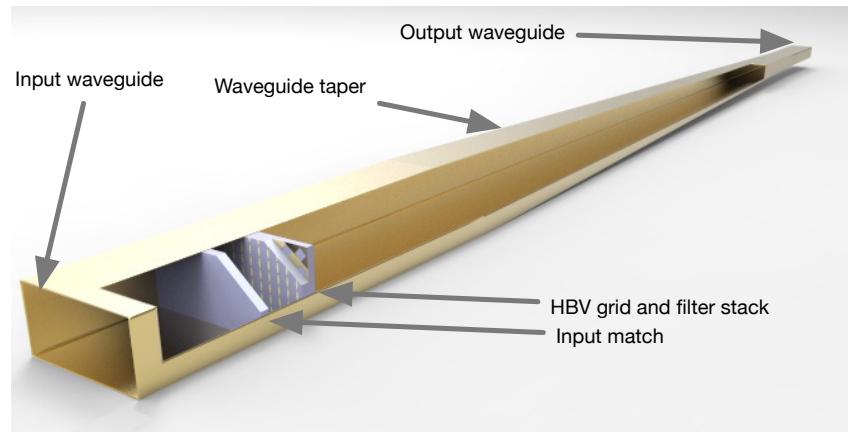
Waveguide enclosed



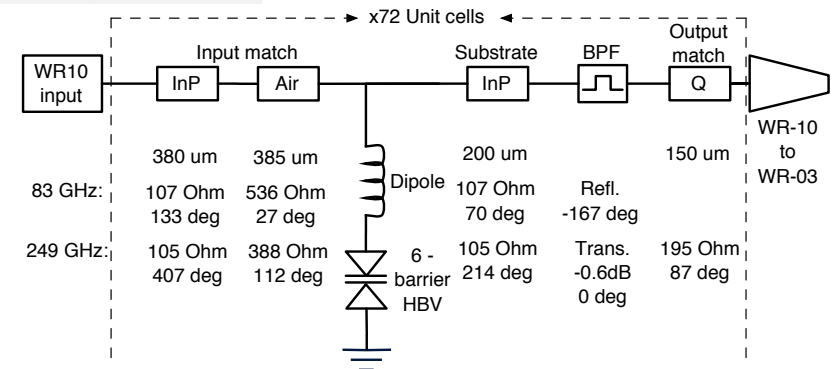
Waveguide enclosed diode array



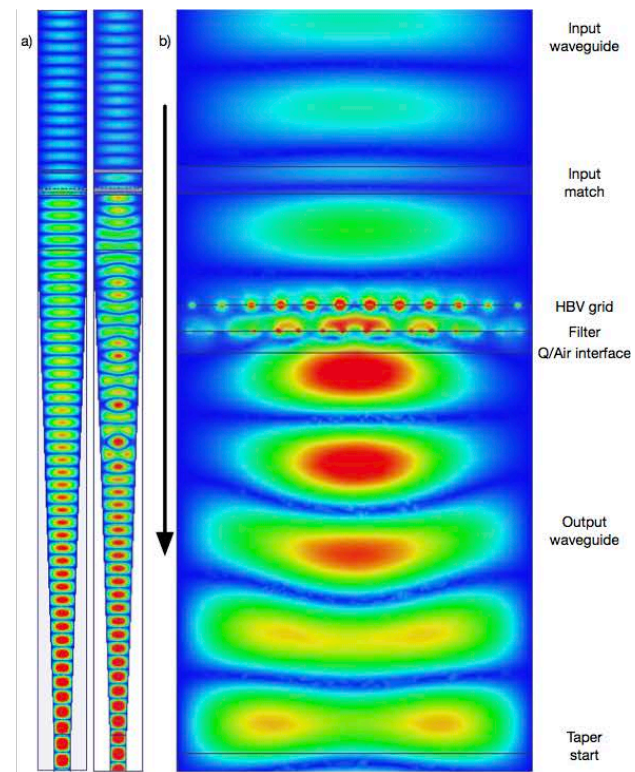
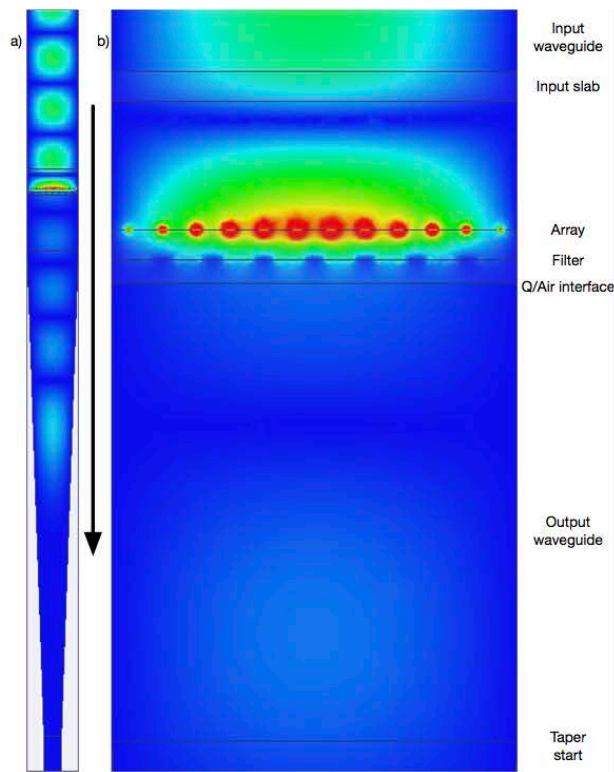
Simulation and design challenge



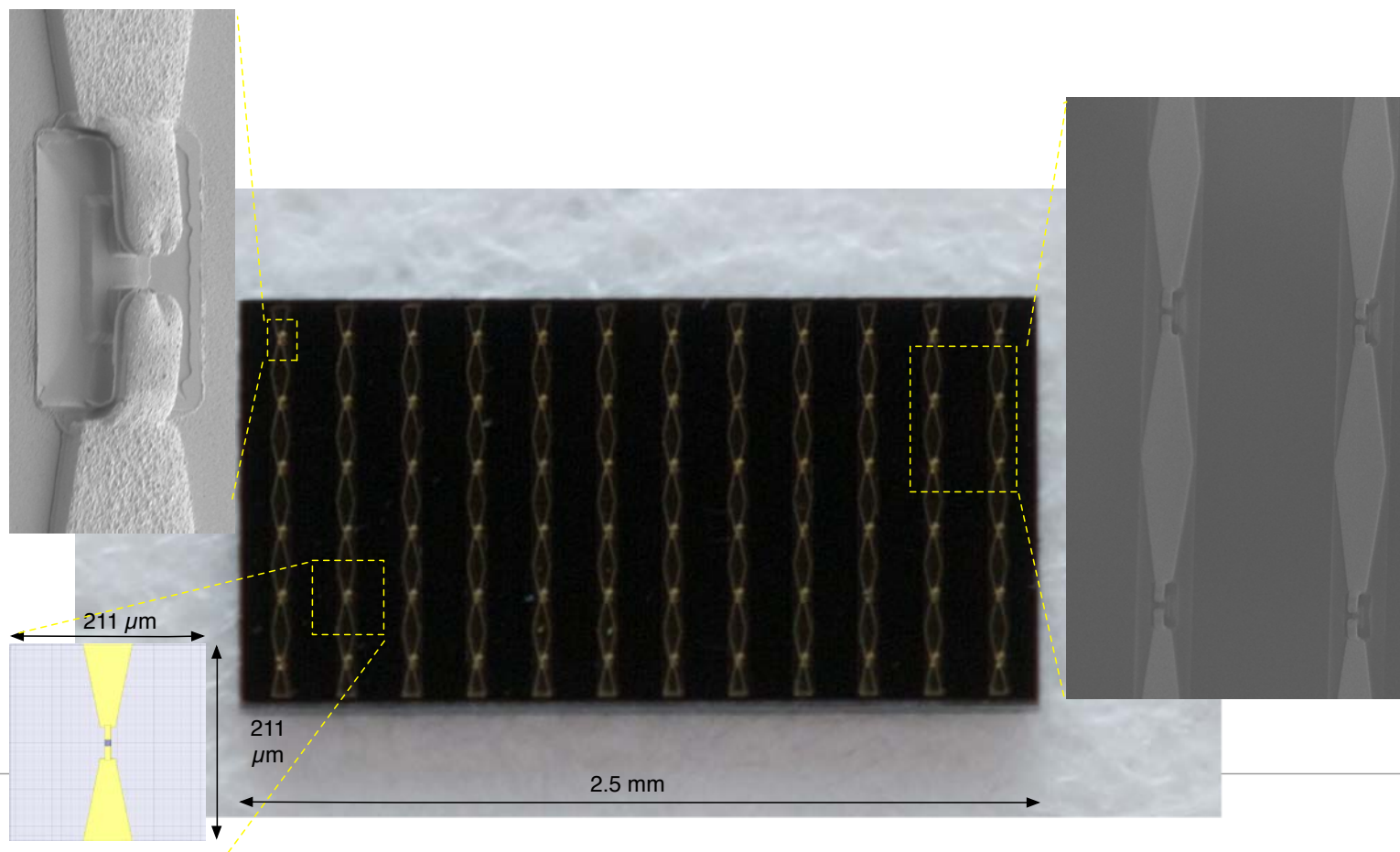
versus



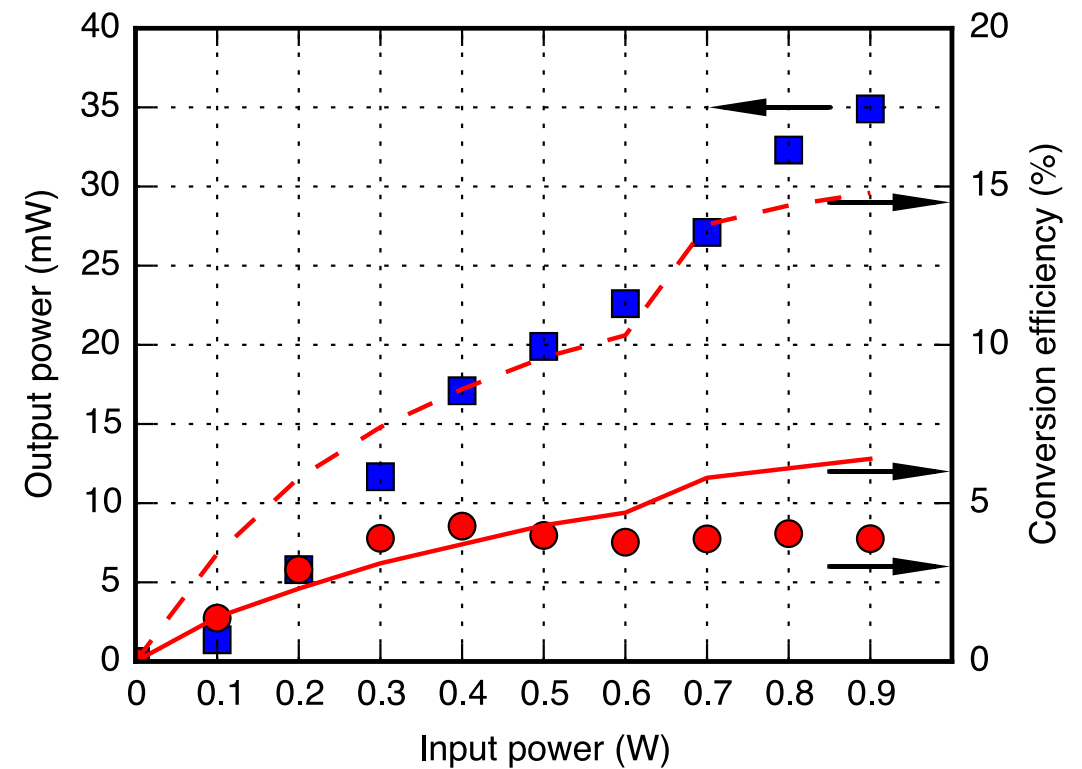
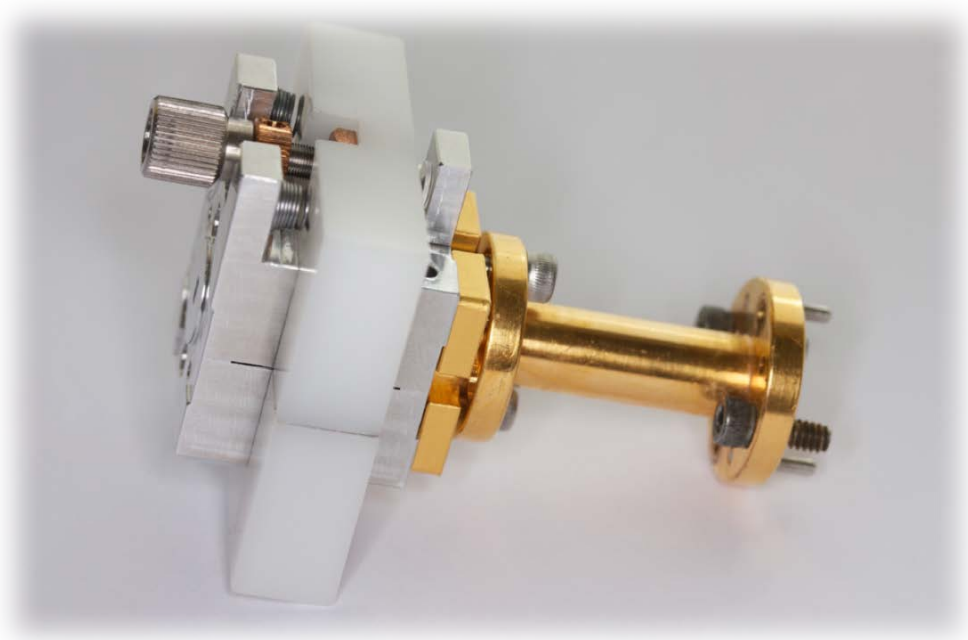
Simulation and design challenge



HBV grid tripler

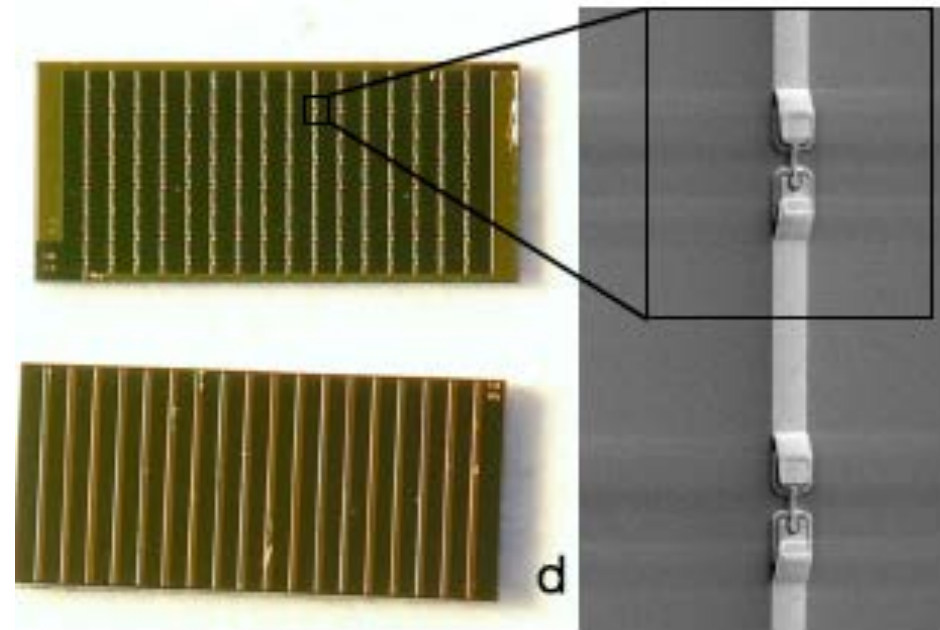
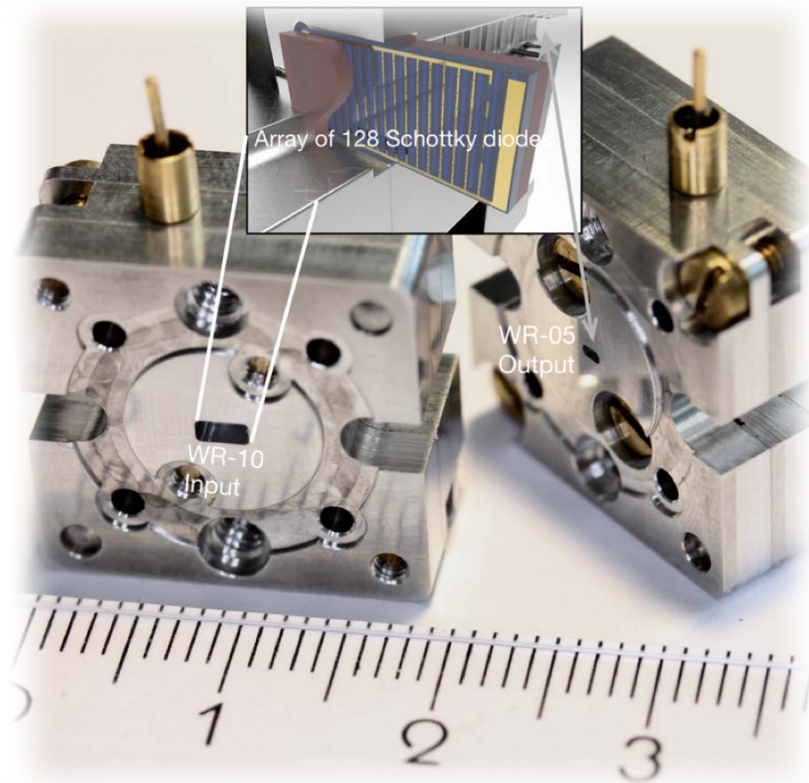


247 GHz HBV grid tripler



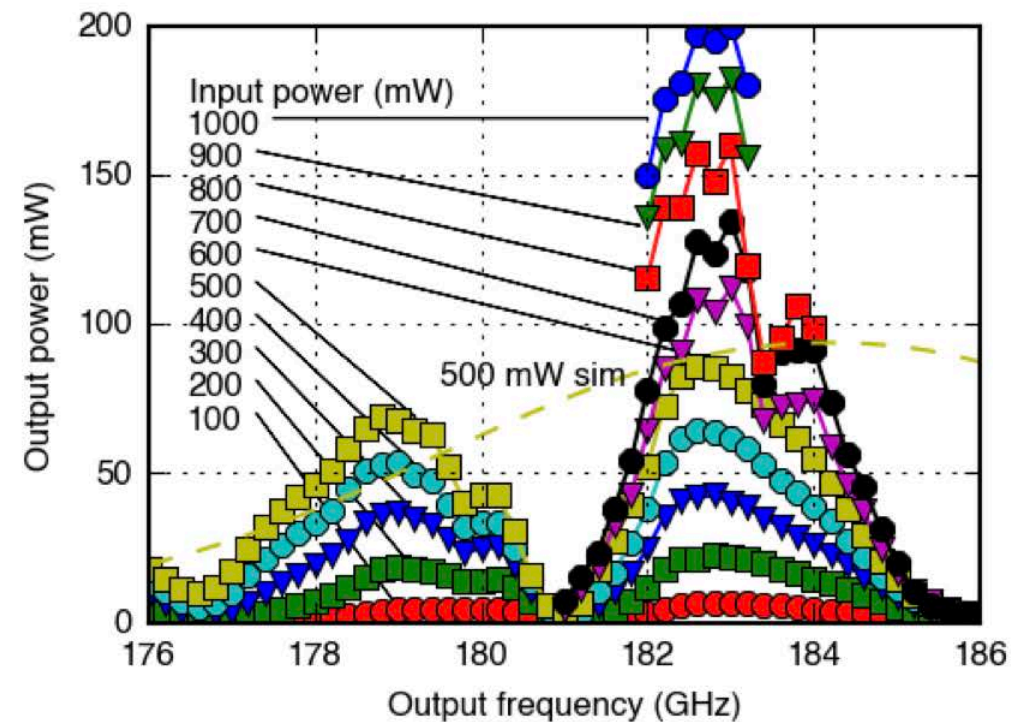
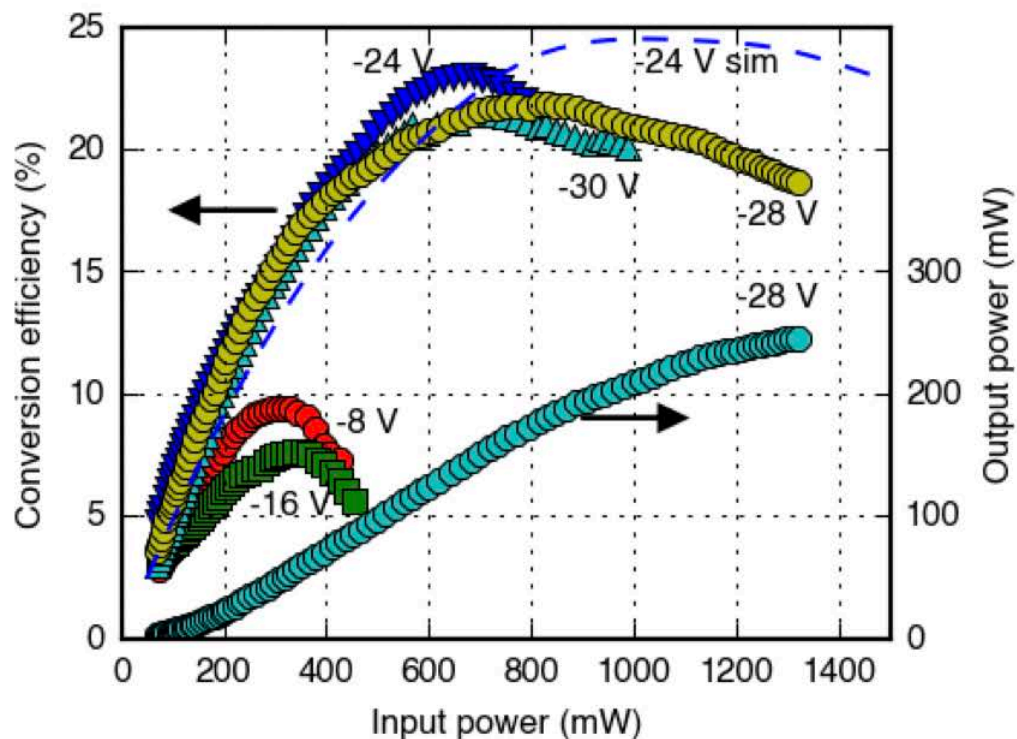
R. Dahlbäck, J. Vukusic, R. M. Weikle II, and J. Stake, "A tunable 240–290 GHz waveguide enclosed 2-D grid HBV frequency tripler," *IEEE Trans. Terahertz Sci. Technol.*, vol. 6, no. 3, pp. 503–509, Apr. 2016.

128-element Schottky diode doubler



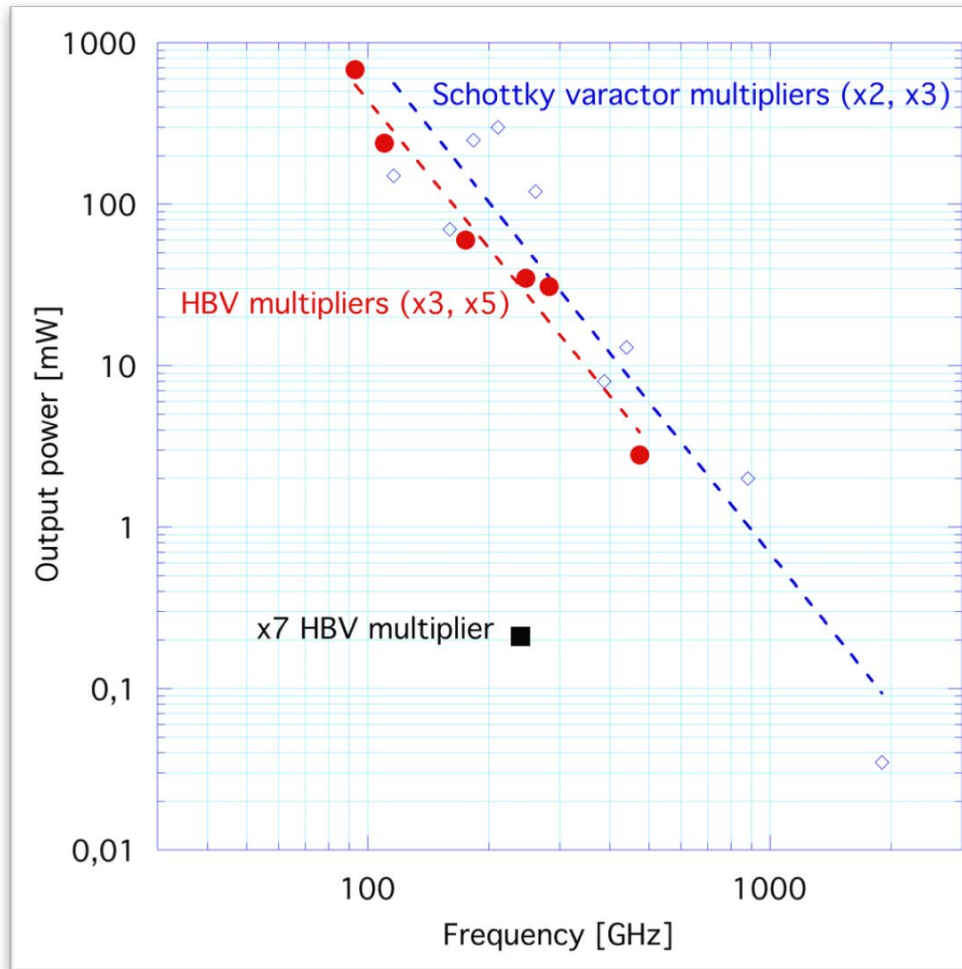
R. Dahlbäck, V. Drakinskiy, J. Vukusic, and J. Stake, "A compact 128-element Schottky diode grid frequency doubler generating 0.25 W of output power at 183 GHz," *IEEE Microw. Wireless Compon. Lett.*, vol. 27, no. 2, Feb. 2017.

128-element Schottky diode doubler

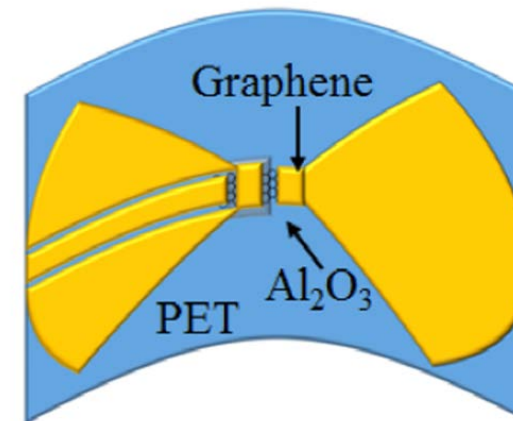
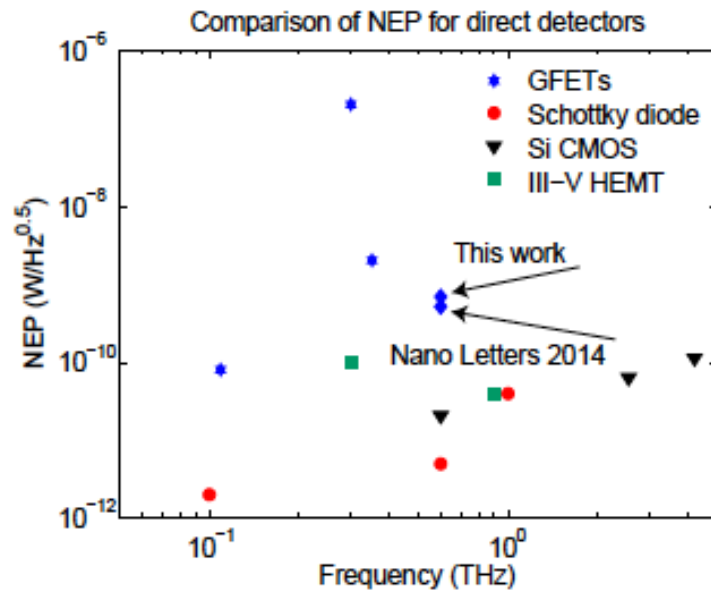


R. Dahlbäck, V. Drakinskiy, J. Vukusic, and J. Stake, "A compact 128-element Schottky diode grid-frequency doubler generating 0.25 W of output power at 183 GHz," *IEEE Microw. Wireless Compon. Lett.*, vol. 27, no. 2, Feb. 2017.

State-of-the-art frequency multipliers



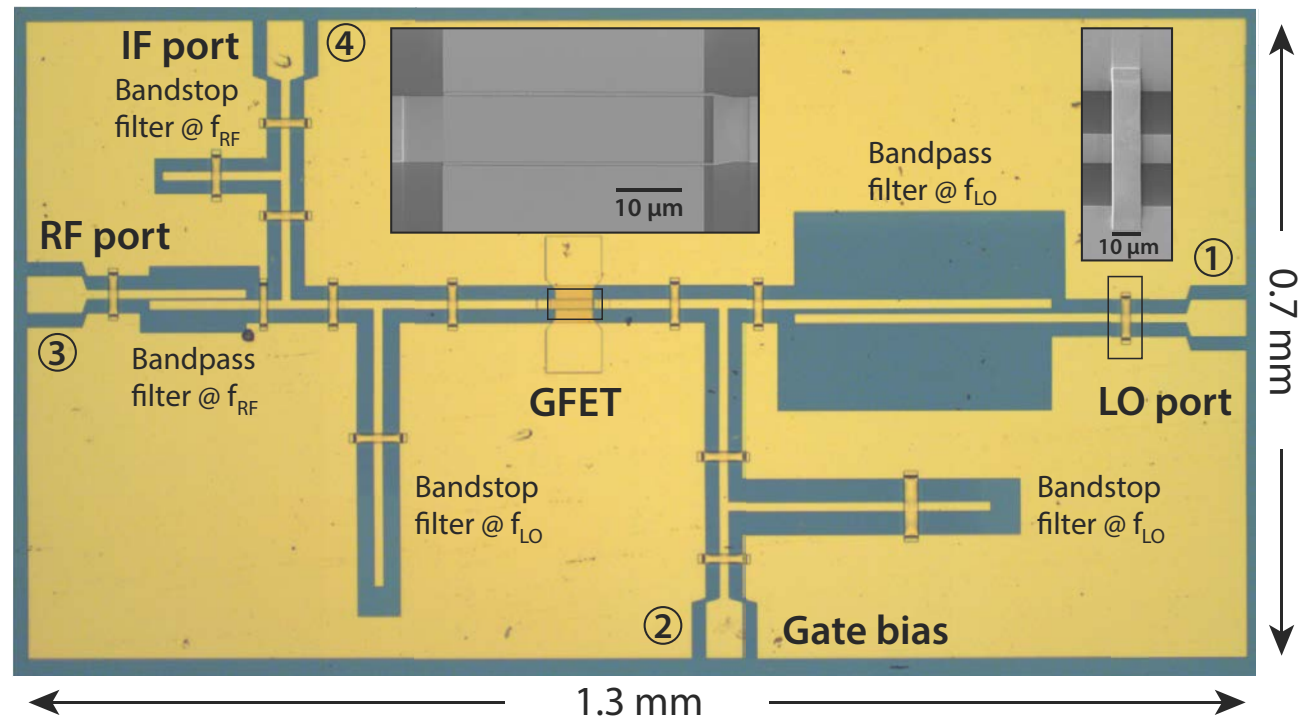
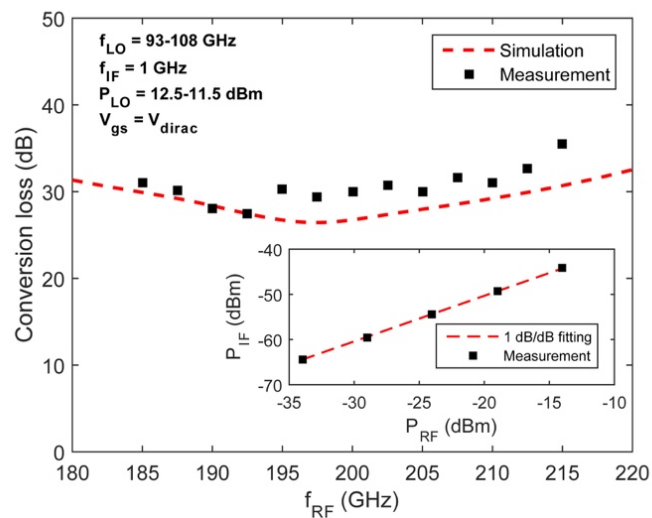
THz Graphene detectors



Flexible THz Technology?

Graphene heterodyne FET mixers

- ⊗ New type of subharmonic FET mixer



Nanofabrication Laboratory

Part of Swedish micro and nano fabrication network

- **Dedicated process lines**
- **Deposition and etching tools**
- **Electron beam lithography**
- **Stepper, Laser writers**
- **Molecular Beam Epitaxy**

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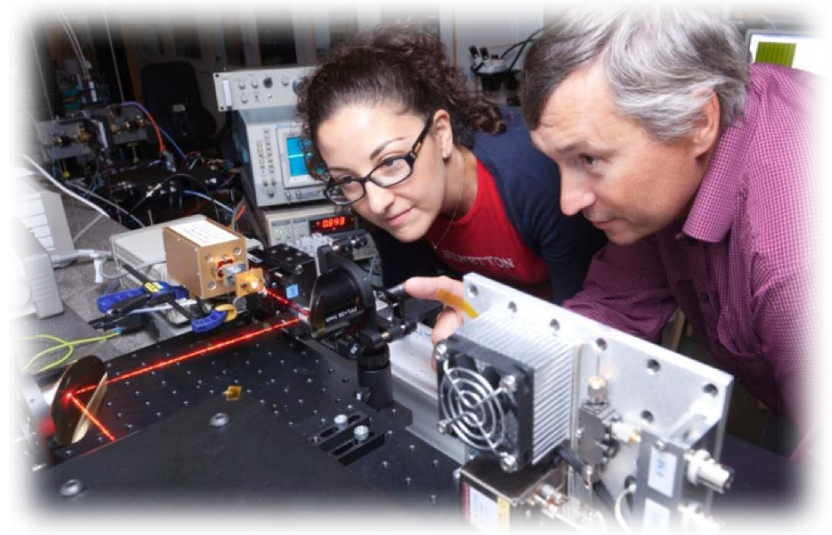


Kollberg Laboratory

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Chalmers national facility for terahertz characterisation

- **Open facility – unique capability**
- **2-port S-parameters up to 1.5 THz**
- **FTS, TDS**
- **Sources**
- **Antenna set-up**
- **Precision machining facility**



Conclusions

- ❊ Nanotechnology and new materials can bring new device concepts such as fundamental oscillators and harmonic generators
- ❊ Develop an integration platform, or heterogeneous integration, is a necessity for future THz arrays

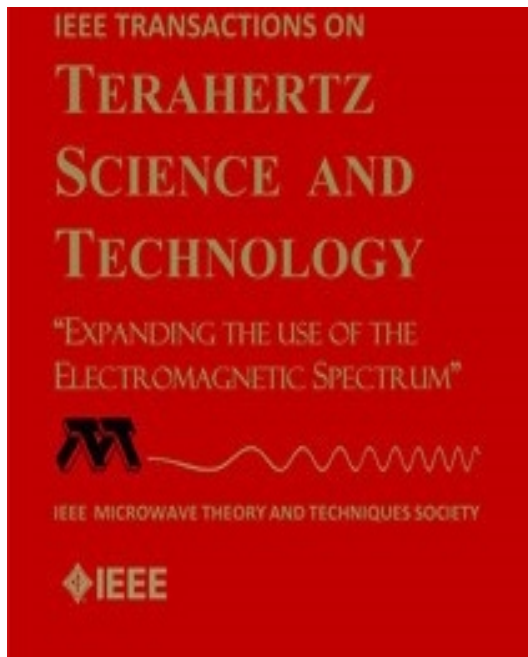


THz and millimetre wave lab



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IEEE Transactions on Terahertz Science and Technology



Expanding the use of the electromagnetic spectrum